



Adsorption and in-diffusion of Hydrogen at metal and metal oxide surfaces

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M. Wilde, K. Kato



Outline

1. Introduction: Interaction of Hydrogen with materials

2. Experimental methods

 Various hydrogen beams

 Nuclear reaction analysis: H depth profiling & site analysis

3. Results and Discussion

- Metal oxides

 Perovskite: SrTiO_3 , High-entropy alloy, ReNiO_3

TiO_2 : rutile vs. anatase

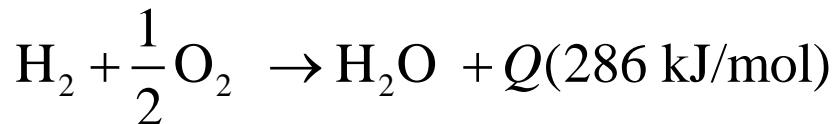
- Metal: metastable hydrides of Pd and Pt

4. Summary

“Surface science / thin film
point of view”

Interaction of Hydrogen with materials

- Hydrogen is a clean energy (no CO₂ emission)



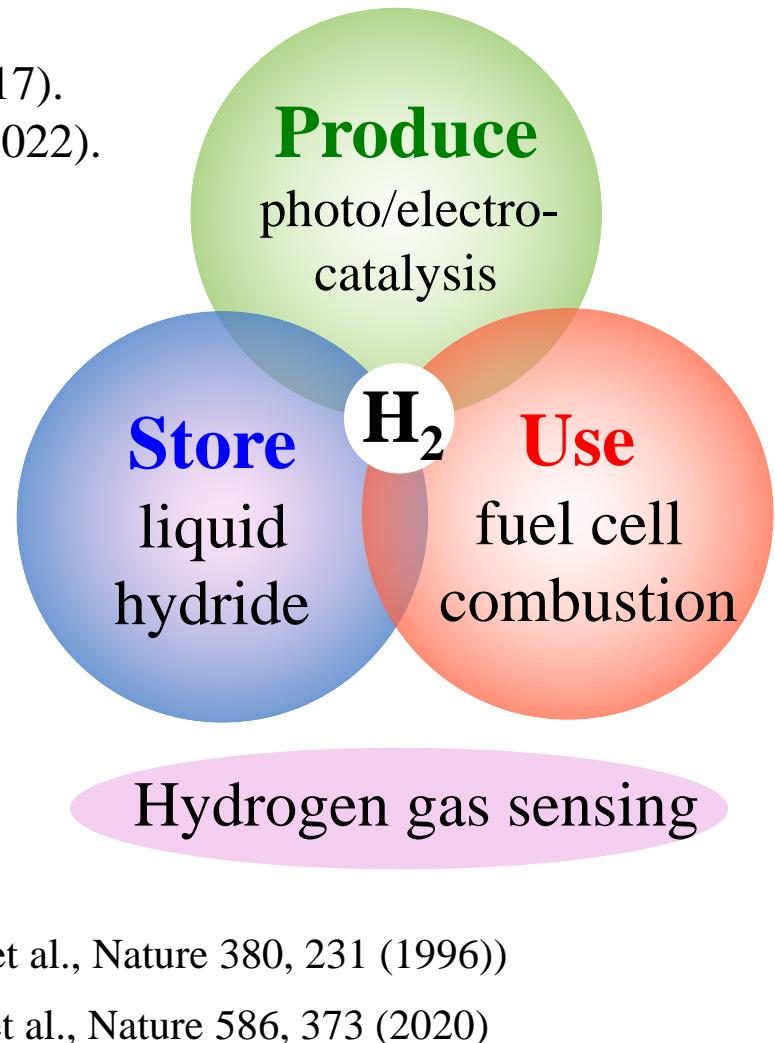
Chem. Rec. 17, 233 (2017).
Catal. Lett. 152, 1583 (2022).

- ✓ Hydrogeneration / de-hydrogenation reactions at surfaces
- ✓ Hydrogen in-diffusion & hydride formation

- Control of physical properties by hydrogen

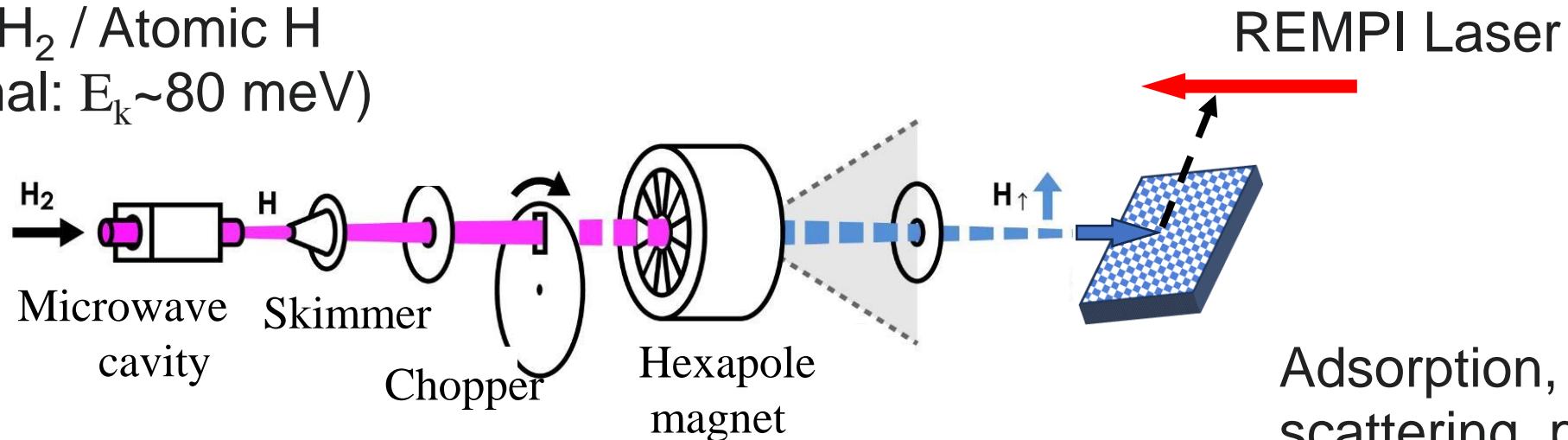
- ✓ Switchable mirrors: YH_x
- ✓ Superconductivity: LaH_x (T_c~240 K)
etc.

(J.N. Huiberts et al., Nature 380, 231 (1996))
E. Snider et al., Nature 586, 373 (2020)



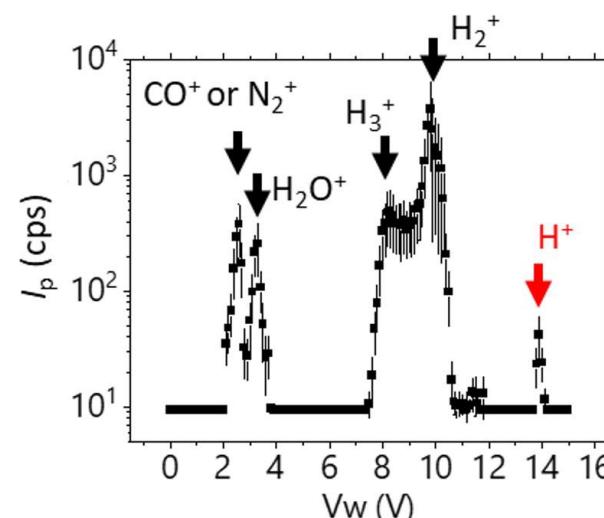
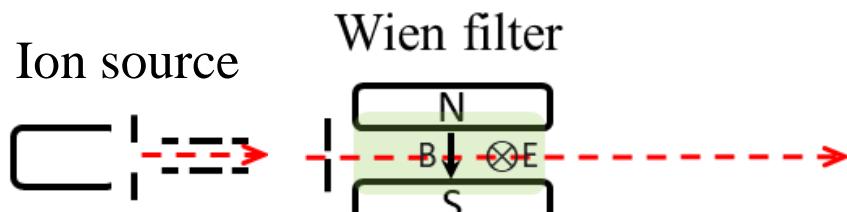
Hydrogen beam

Molecular H₂ / Atomic H
(thermal: E_k~80 meV)



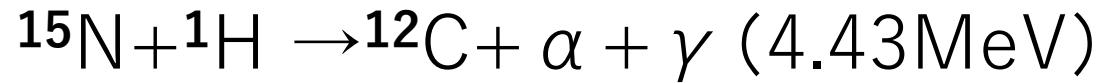
Adsorption, desorption
scattering, permeation

Low-energy H₂⁺, H⁺
(a few eV $\leq E_k \leq 2$ keV)



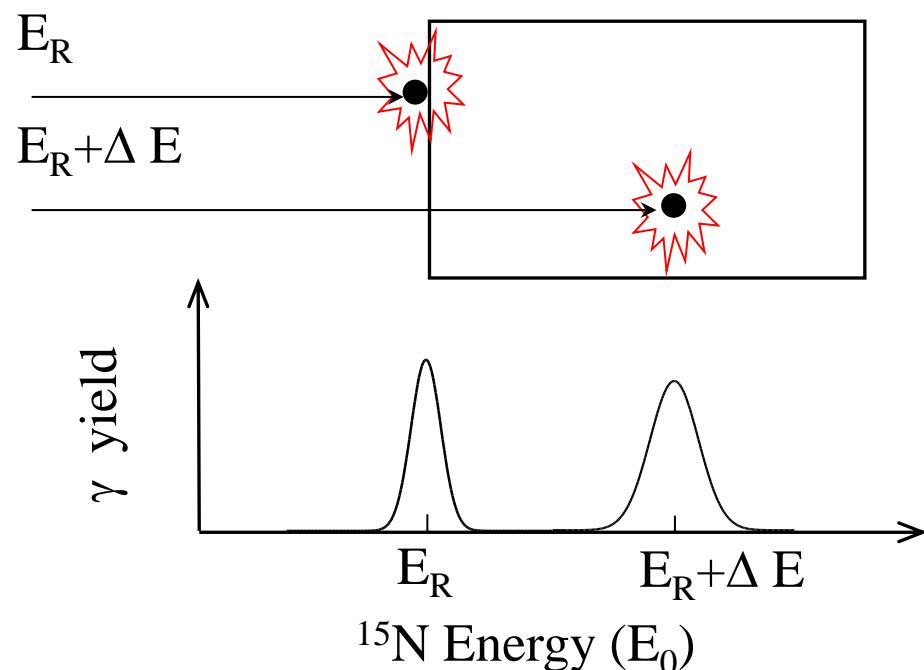
Characterization by
TDS / NRA

Nuclear Reaction Analysis



Resonance at $E_R = 6.385 \text{ MeV}$ Resonance width = 1.8 keV

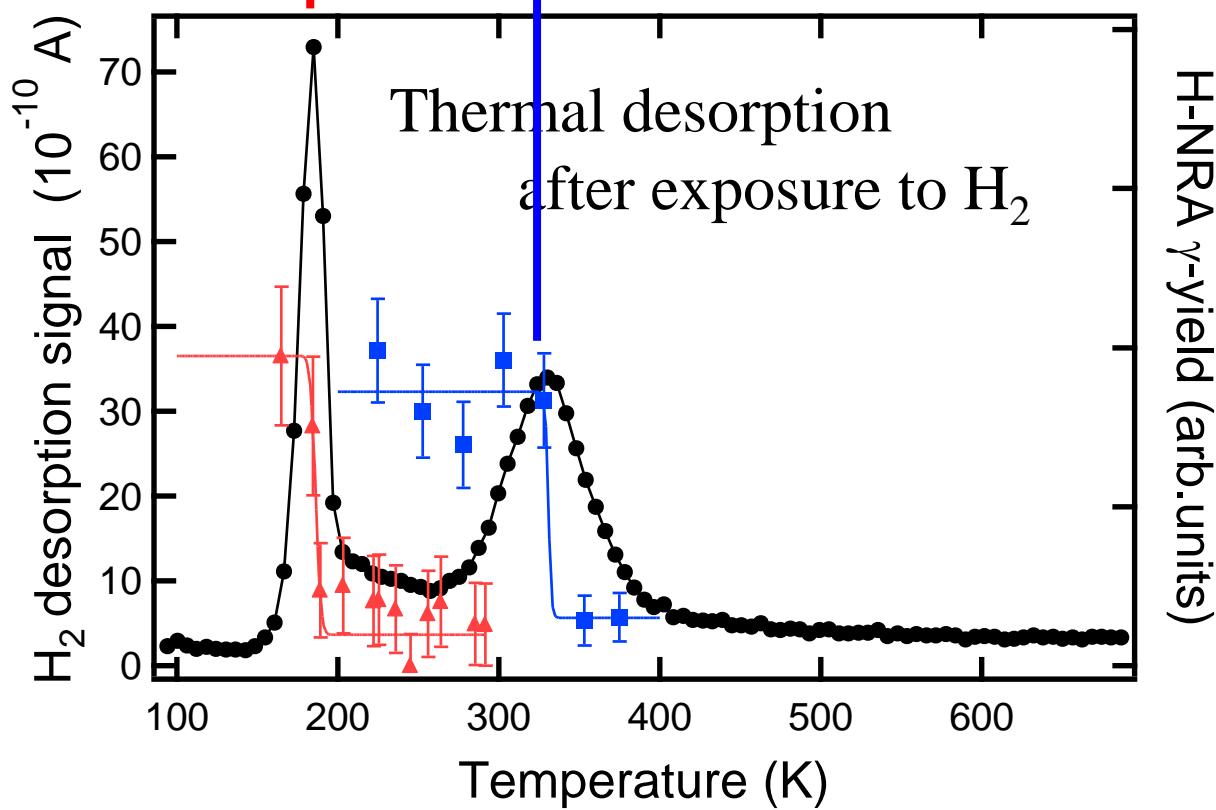
Depth profiling



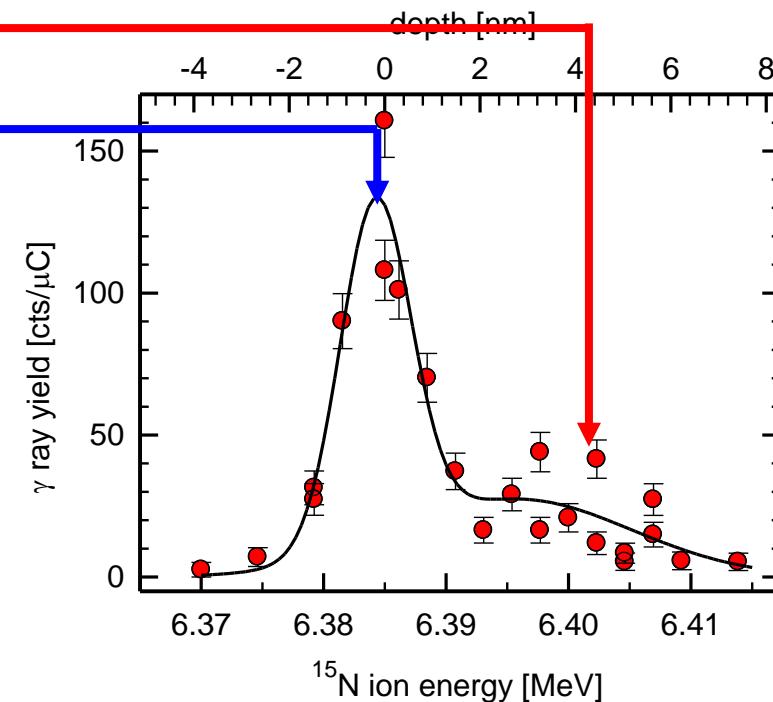
H storage in Pd

NRA depth profile

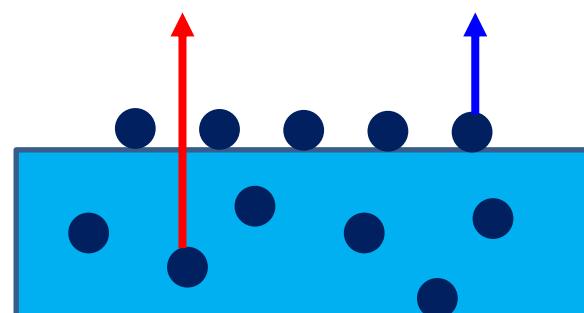
Subsurface H



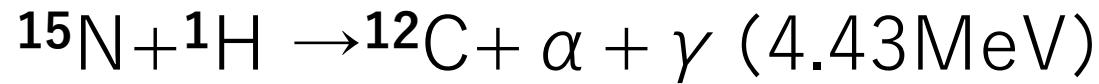
Surf. Sci. 482-485 (2001) 346; Phys. Rev. B 78 (2008) 115411.



$$T_b = 180 \text{ K} \quad T_s = 330 \text{ K}$$

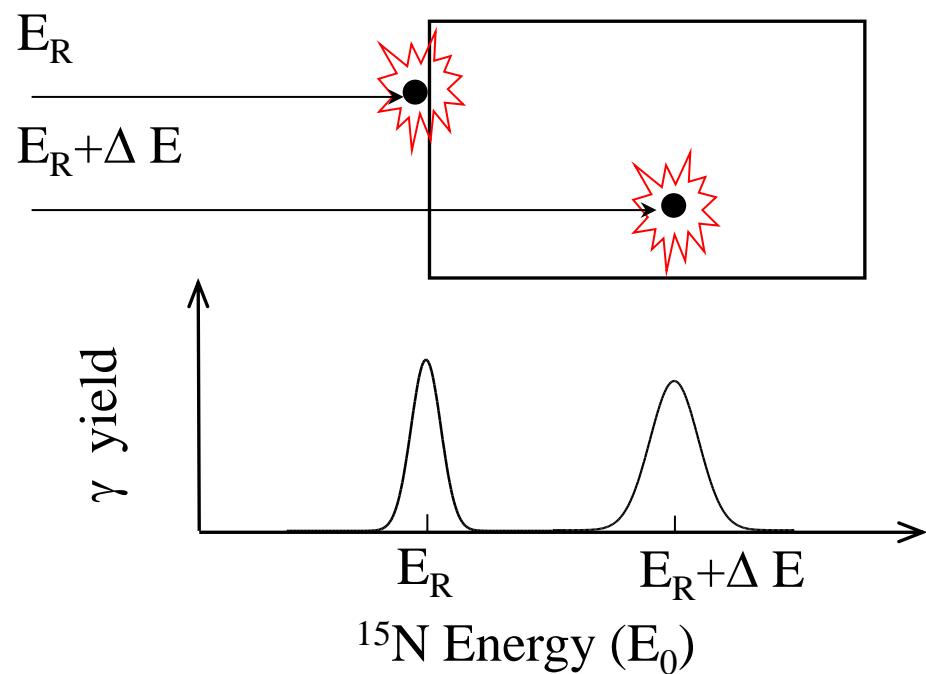


Nuclear Reaction Analysis

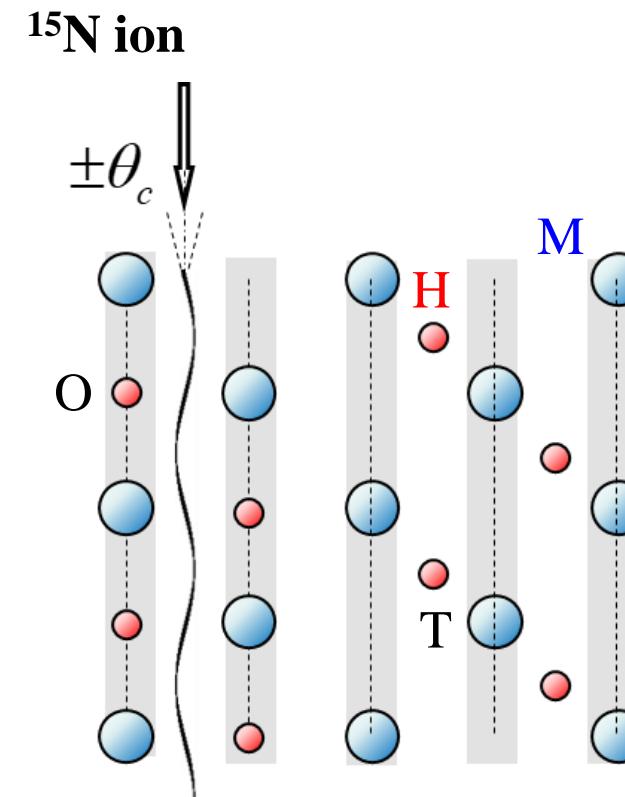


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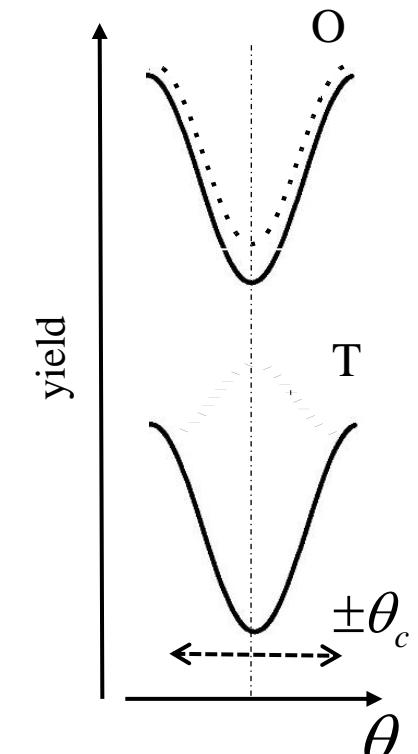
Depth profiling



Channeling

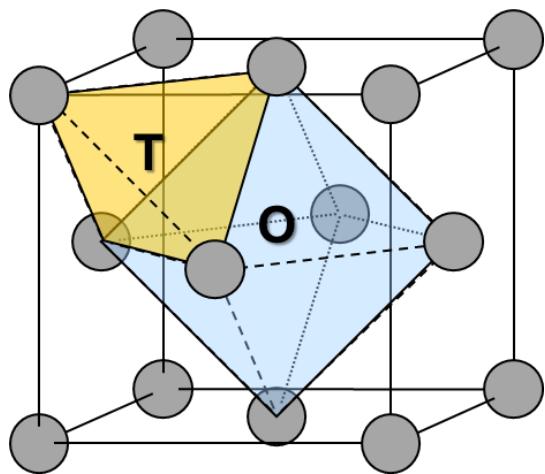


Site analysis



Analysis of H location: TiH_{2-x}

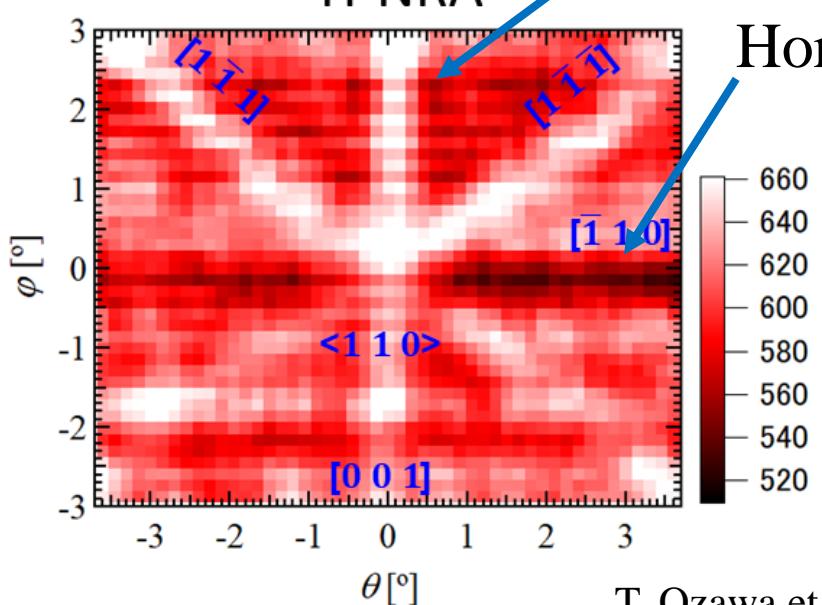
Fcc



Visible
Hidden

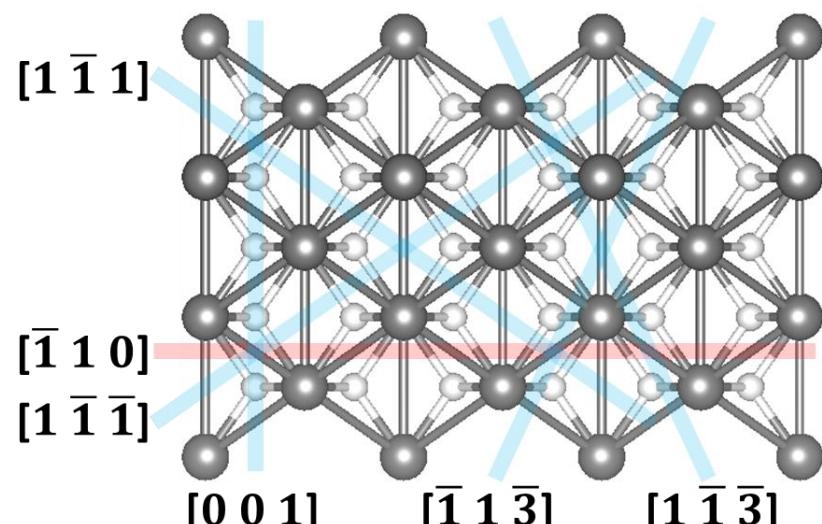
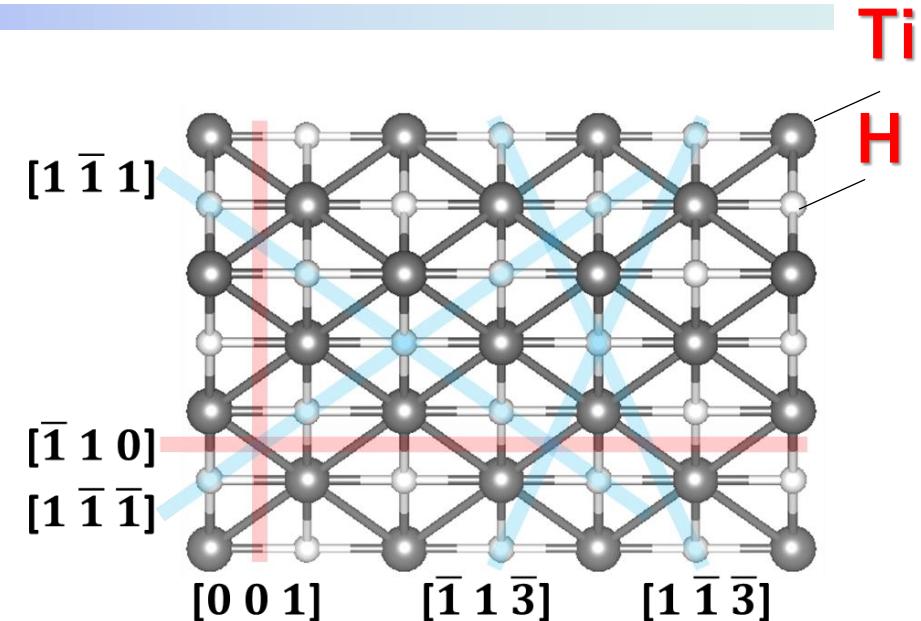
H in
O site

Vertical: bright
Horizontal: dark



H in
T site

10% H in
O site



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Perovskite: SrTiO_3 , High-entropy alloy, ReNiO_3

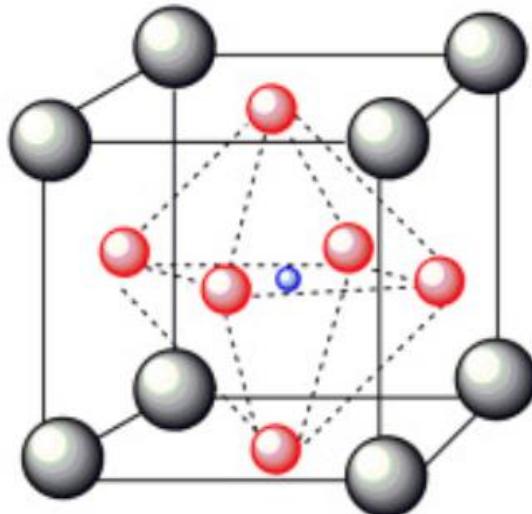
TiO_2 : rutile vs. anatase

- Metal: metastable hydrides of Pd and Pt

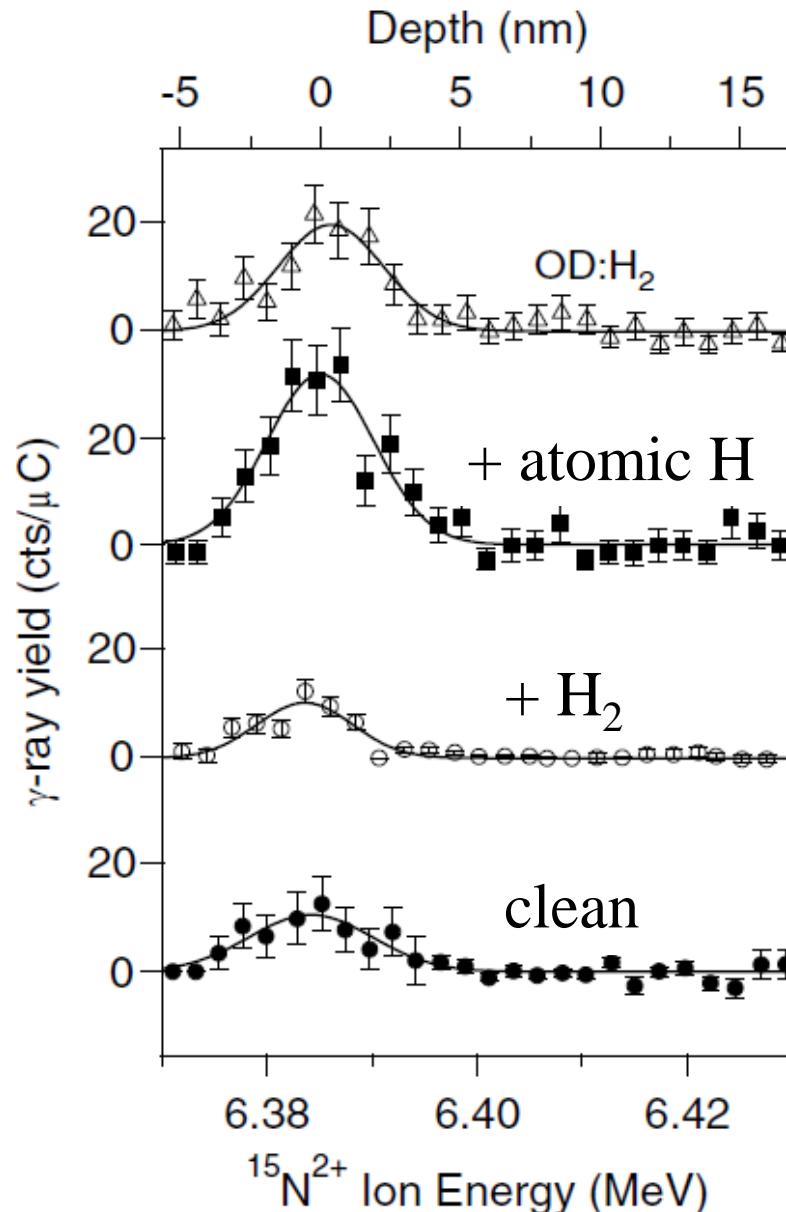
4. Summary

Perovskite metal oxide: SrTiO₃ (001)

SrTiO₃ (001)



Two types of surfaces
SrO & TiO₂ (001)



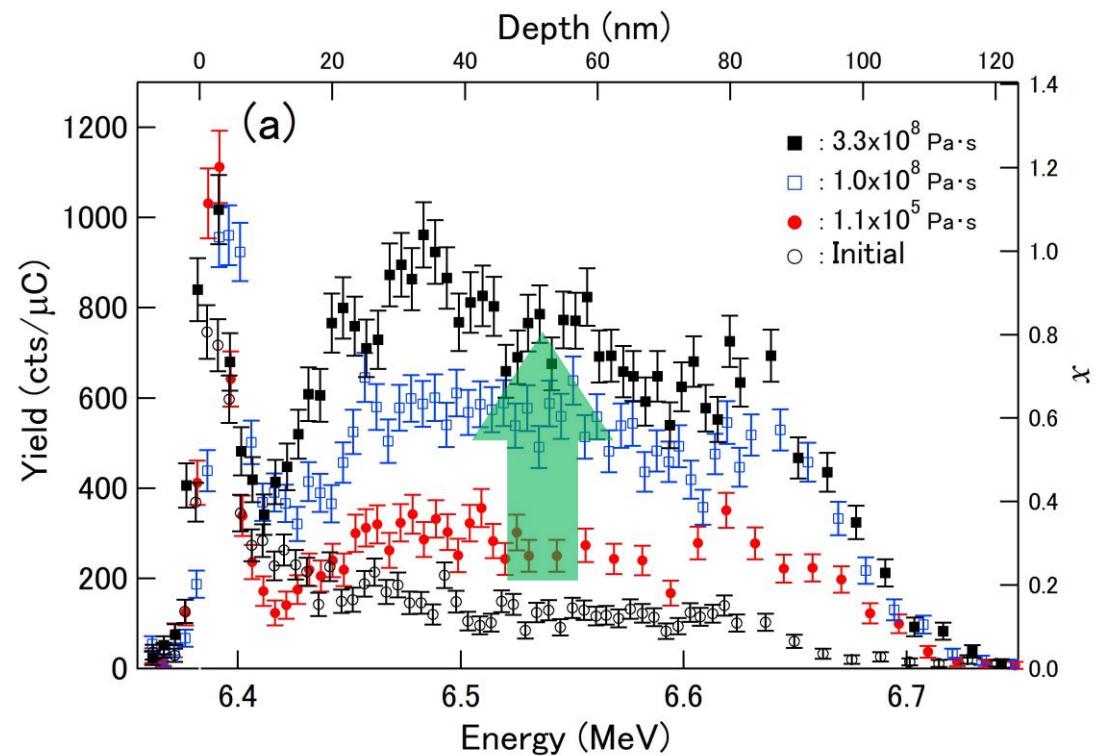
H-induced conductivity
= Dielectric breakdown

H density
 $3.1 \pm 0.7 (10^{14} \text{ cm}^{-2})$

No adsorption with H₂
= Activation barrier
for H₂ dissociation

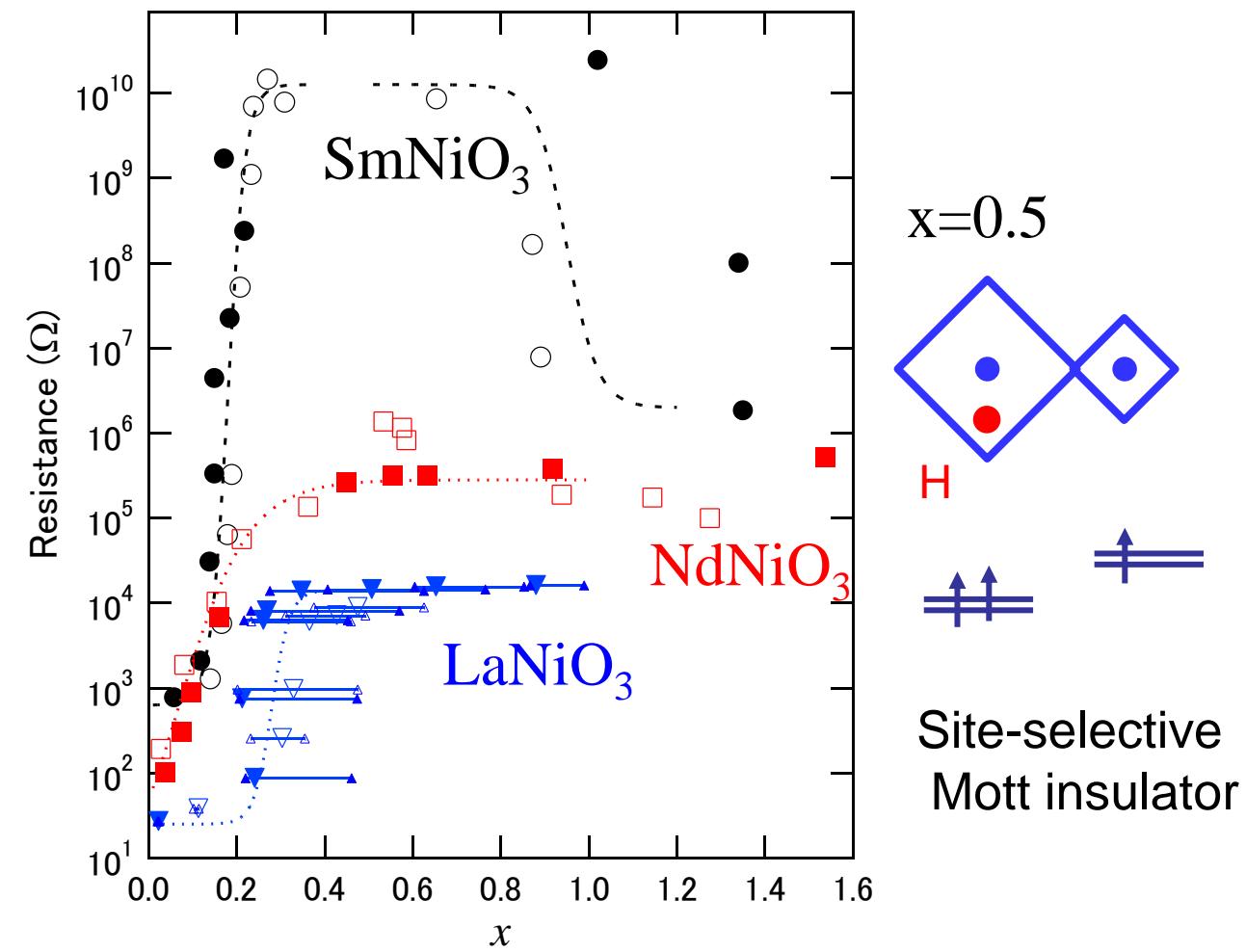
ReNiO_3 (Re=Sm, Nd, La)

Pt (20nm) / SmNiO_3H_x (70 nm) / LaAlO_3



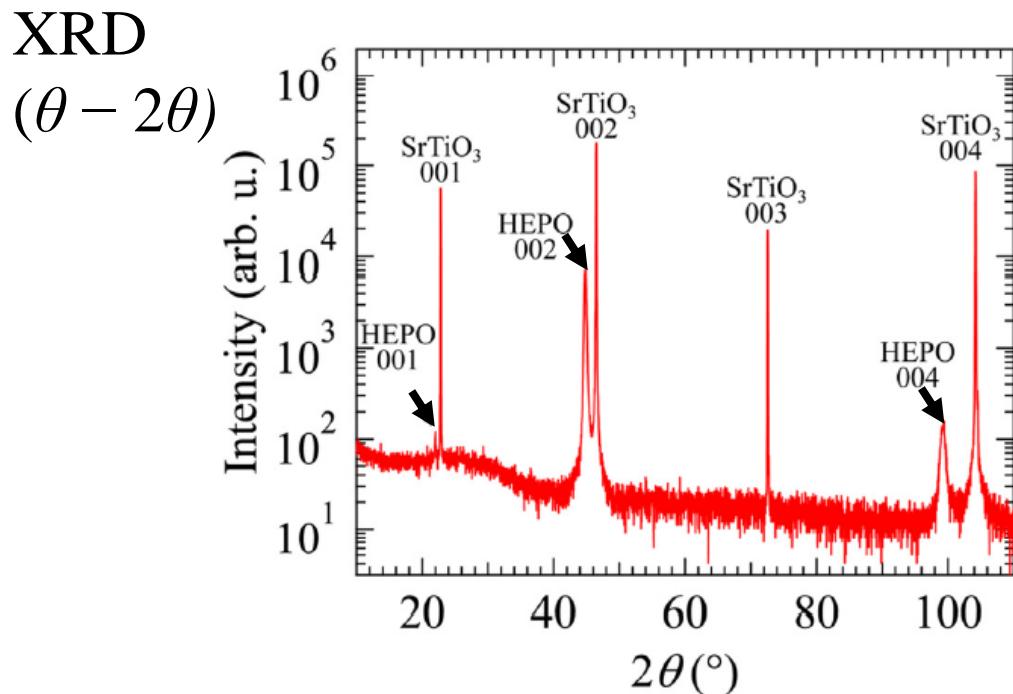
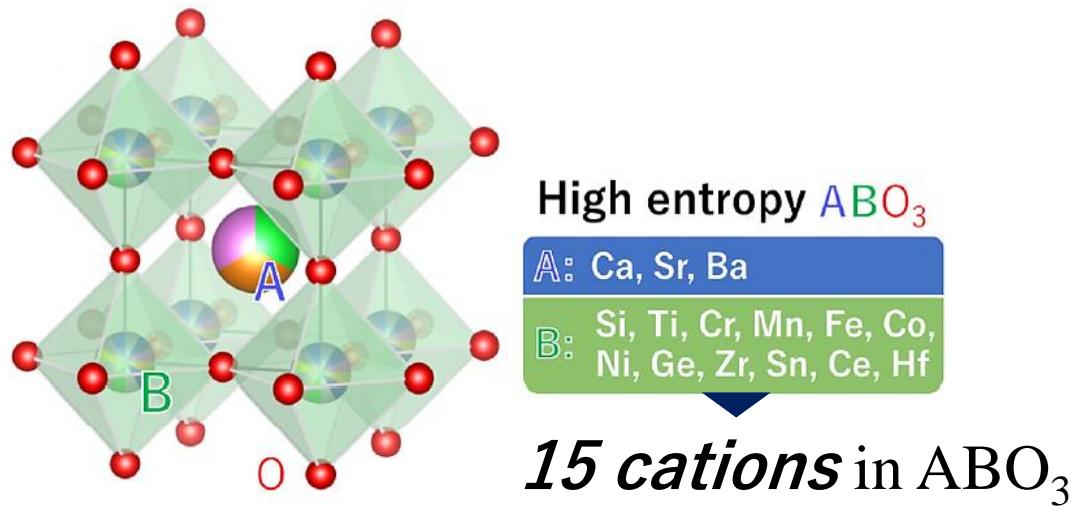
Hydrogen concentration (x) increases almost uniformly up to $x \sim 1$

(Phys. Rev. Mater. 7, 085003 (2023))



H-induced metal-to-insulator transition

High-entropy perovskite oxide (HEPO)



Pulsed laser deposition on $\text{SrTiO}_3(001)$

T=873 K, P(O₂)=0.13 Pa
Thickness=90 nm

ICP-MS
(compositional analysis)

3 elements
A site

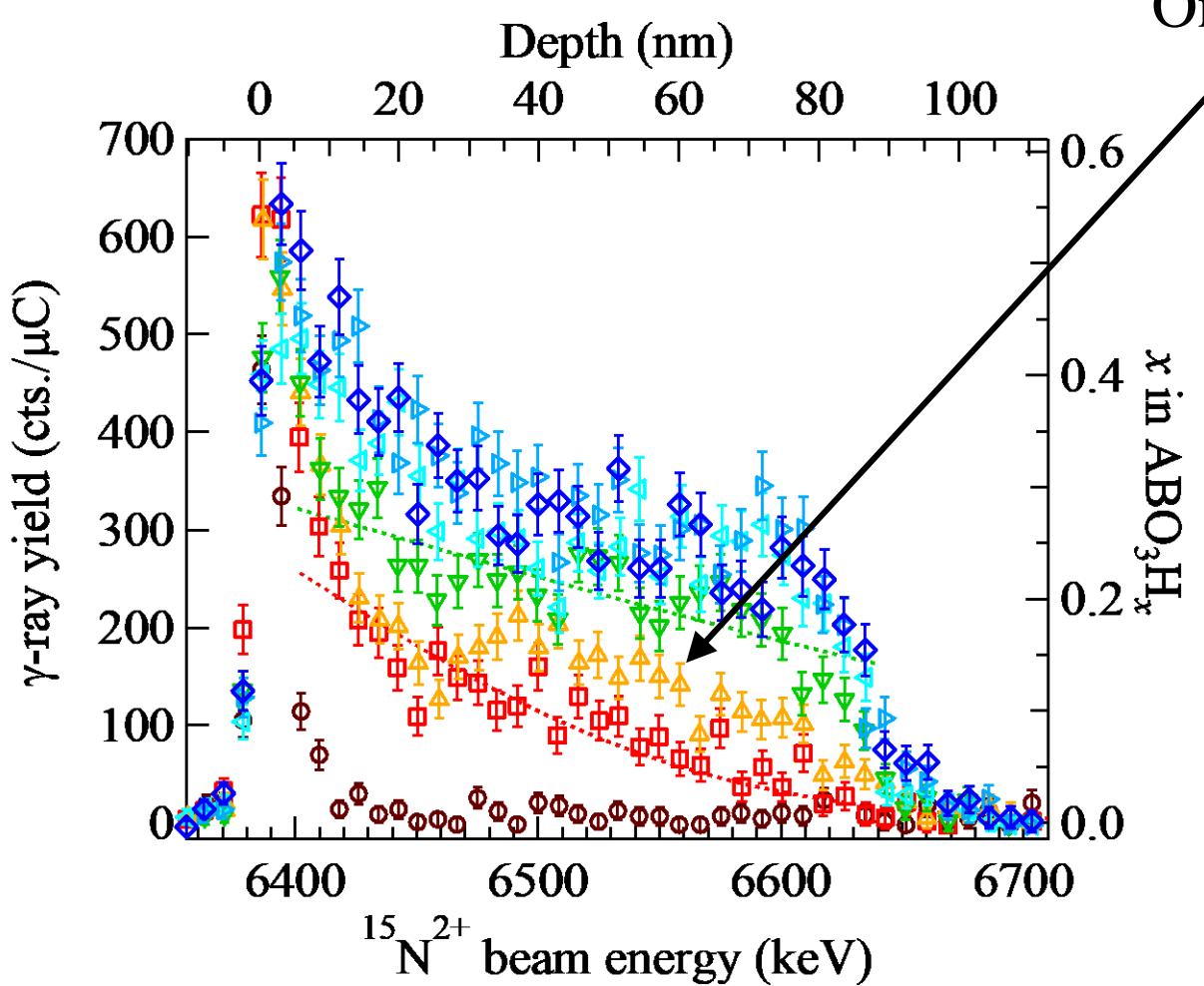
Ca	Sr	Ba
0.305 ± 0.008	0.111 ± 0.011	0.097 ± 0.008

B site

Si	Ti	Cr
Not detected	0.162 ± 0.038	0.028 ± 0.005
Co	Ni	Ge
0.022 ± 0.005	0.021 ± 0.006	0.018 ± 0.002
Ce	Hf	
0.014 ± 0.005	0.013 ± 0.009	
Mn	Fe	
0.025 ± 0.005	0.045 ± 0.006	
Zr	Sn	
0.116 ± 0.022	0.021 ± 0.003	

11 elements

Atomic-H dosage to HEPO film



One-dimensional diffusion

$$C = C_s \left(1 - \operatorname{erf} \left[\frac{z}{2\sqrt{Dt}} \right] \right)$$

Diffusion coefficients

$(9.7 \pm 1.5) \times 10^{-15} \text{ cm}^2/\text{s}$ at 365 K

$(4.4 \pm 1.3) \times 10^{-14} \text{ cm}^2/\text{s}$ at 400 K

Activation barrier $(0.54 \pm 0.13) \text{ eV}$

(cf.) H in NdNiO_3 : 0.39-0.76 eV

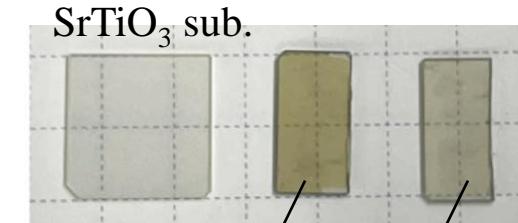
ACS Appl. Electron. Mater. 4 (2022) 4849.

- Resistance

$R > 100 \text{ M}\Omega$ after hydrogenation

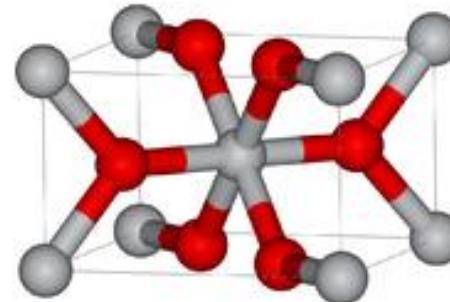
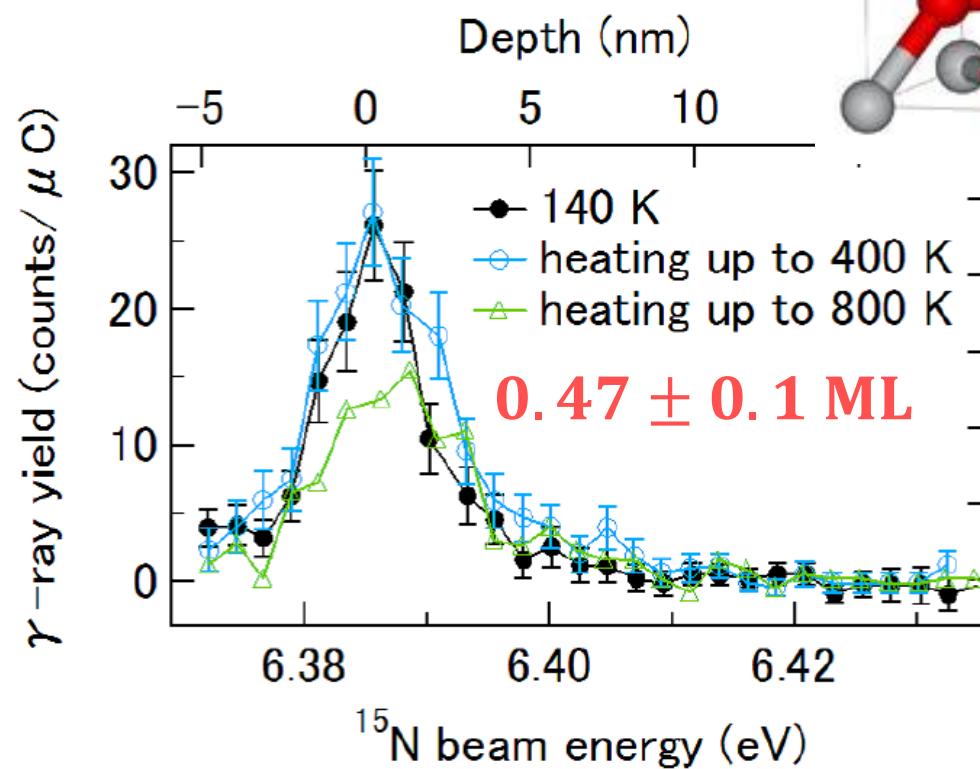
- Optical images

The film gets transparent.



Atomic H dosage to TiO_2

rutile- TiO_2 (110)

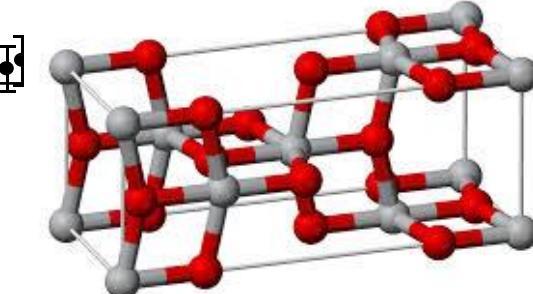
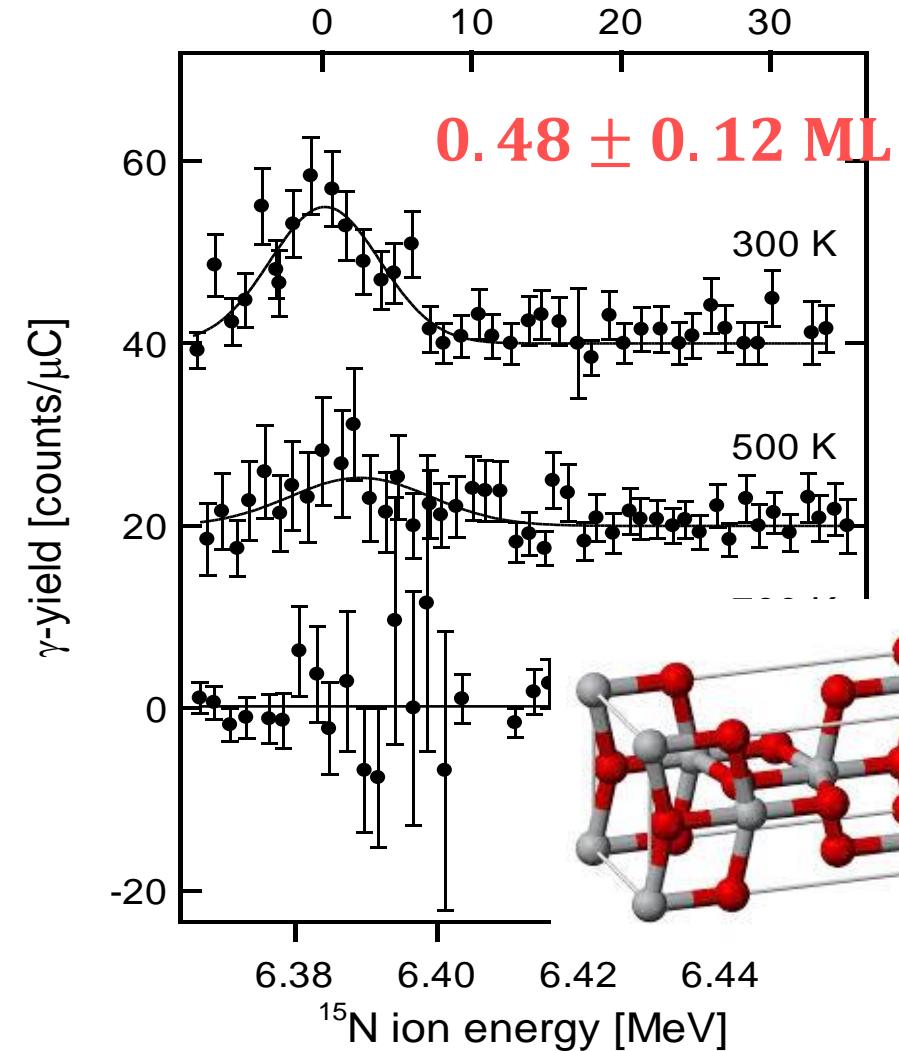


Surface adsorption & little absorption

K. Fukada et al., JPSJ 84, 064716 (2015); PRB 105, 045424 (2022)

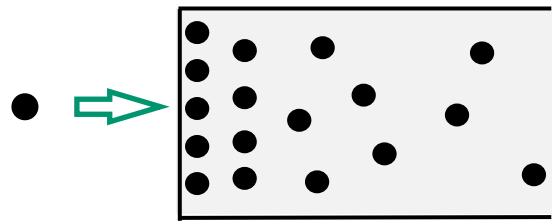
anatase- TiO_2 (101)

Depth [nm]



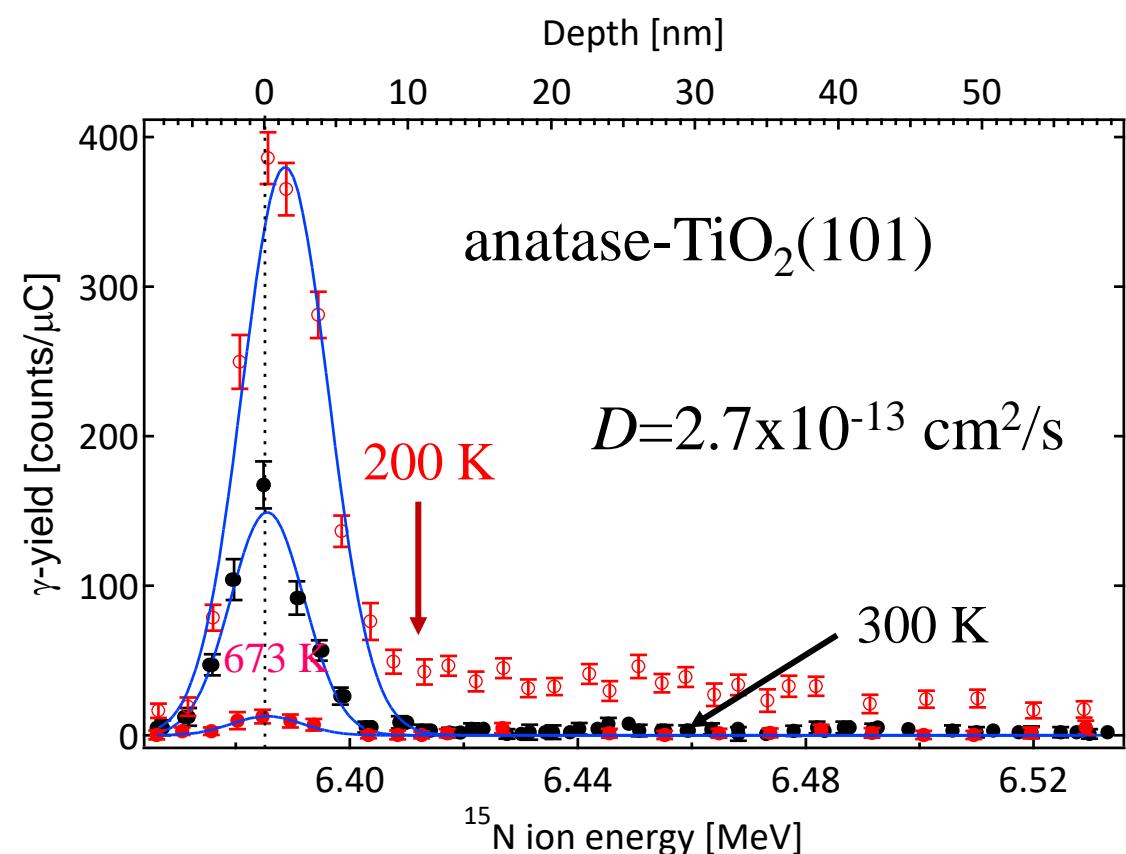
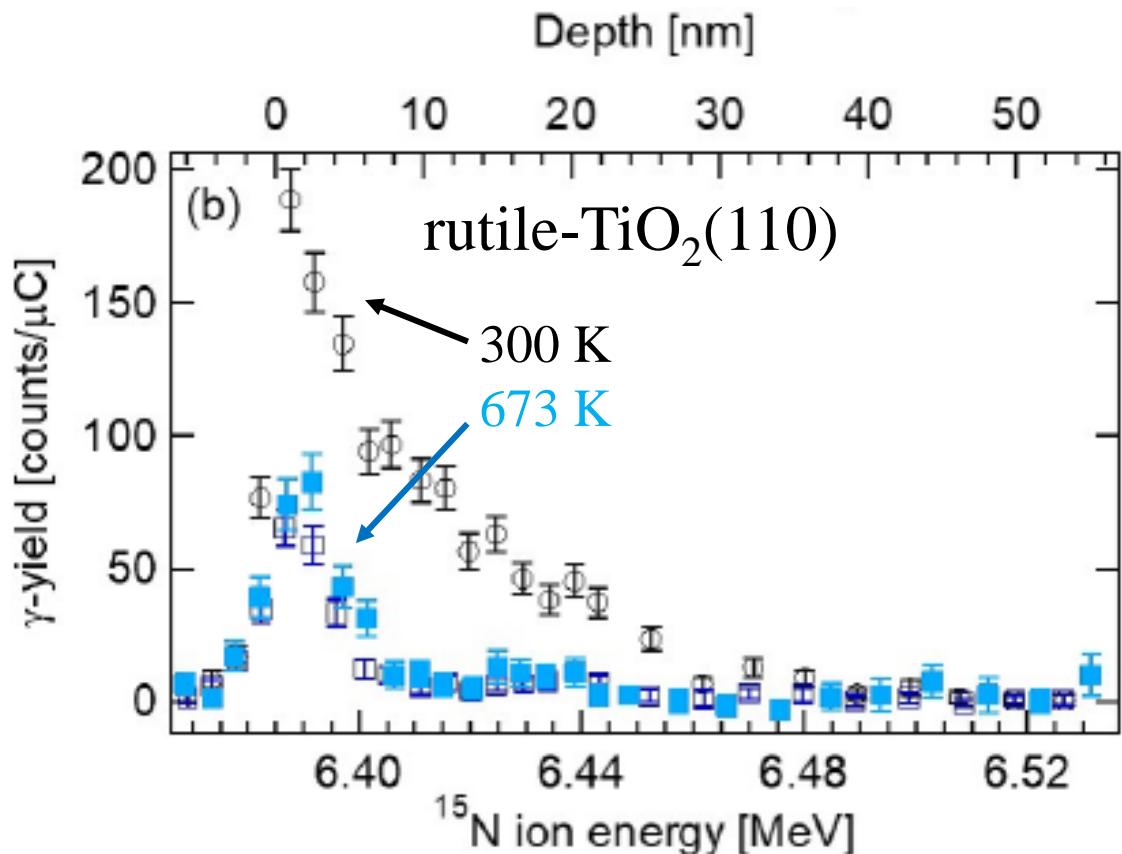
H Depth profile: diffusion analysis in TiO_2

H ion
Irradiation
at 500 eV

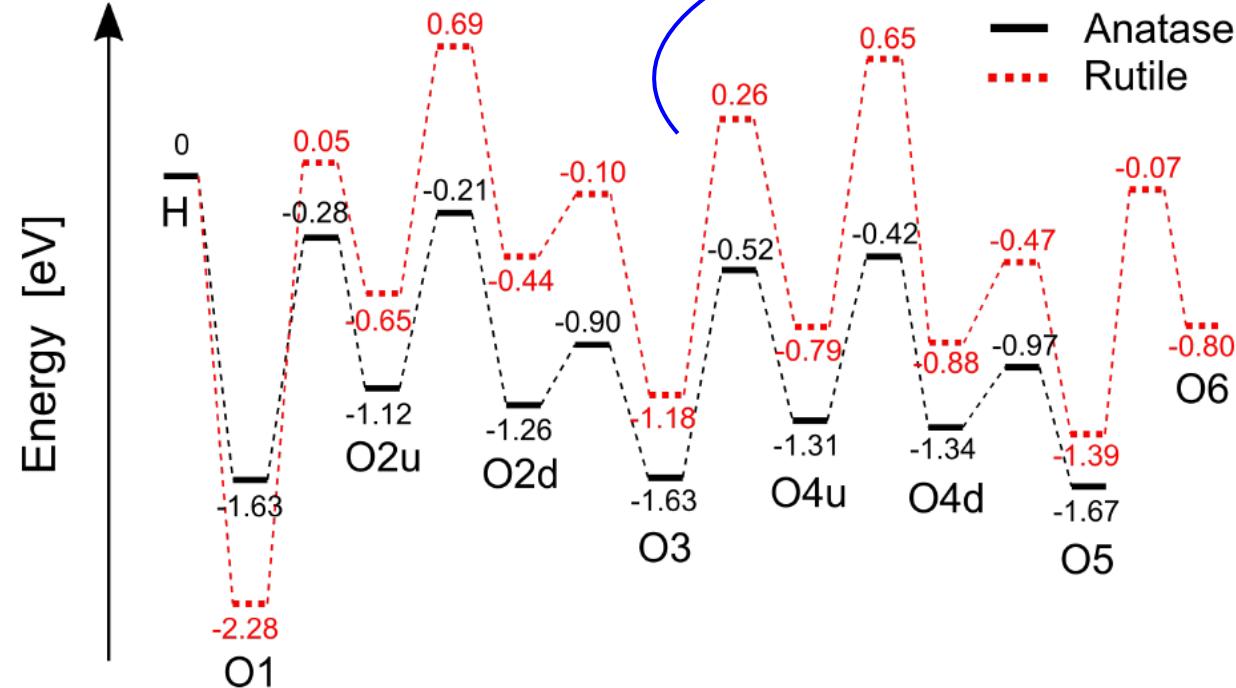
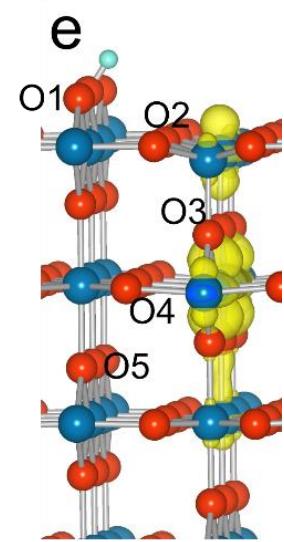
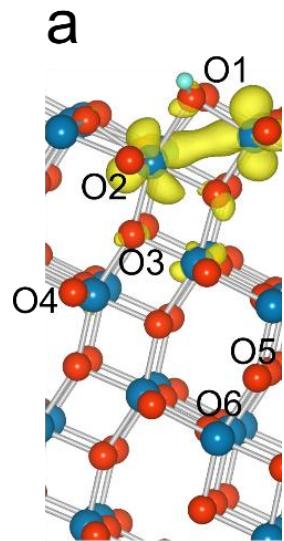


$$c(z,t) = \frac{c_0}{2} \left[1 - \text{erf} \left(\frac{z}{\sqrt{4Dt}} \right) \right]$$

Rutile: $E_a = 0.86 \text{ eV}$
Anatase: $E_a = 0.21 \text{ eV}$



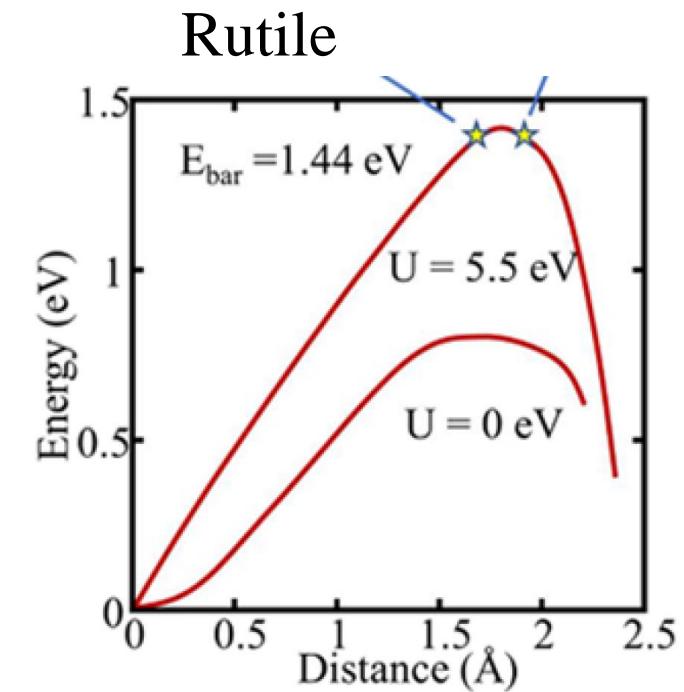
DFT: energy diagram



Rutile: $E_a = 1.83 \text{ eV}$

Anatase: $E_a = 1.21 \text{ eV}$

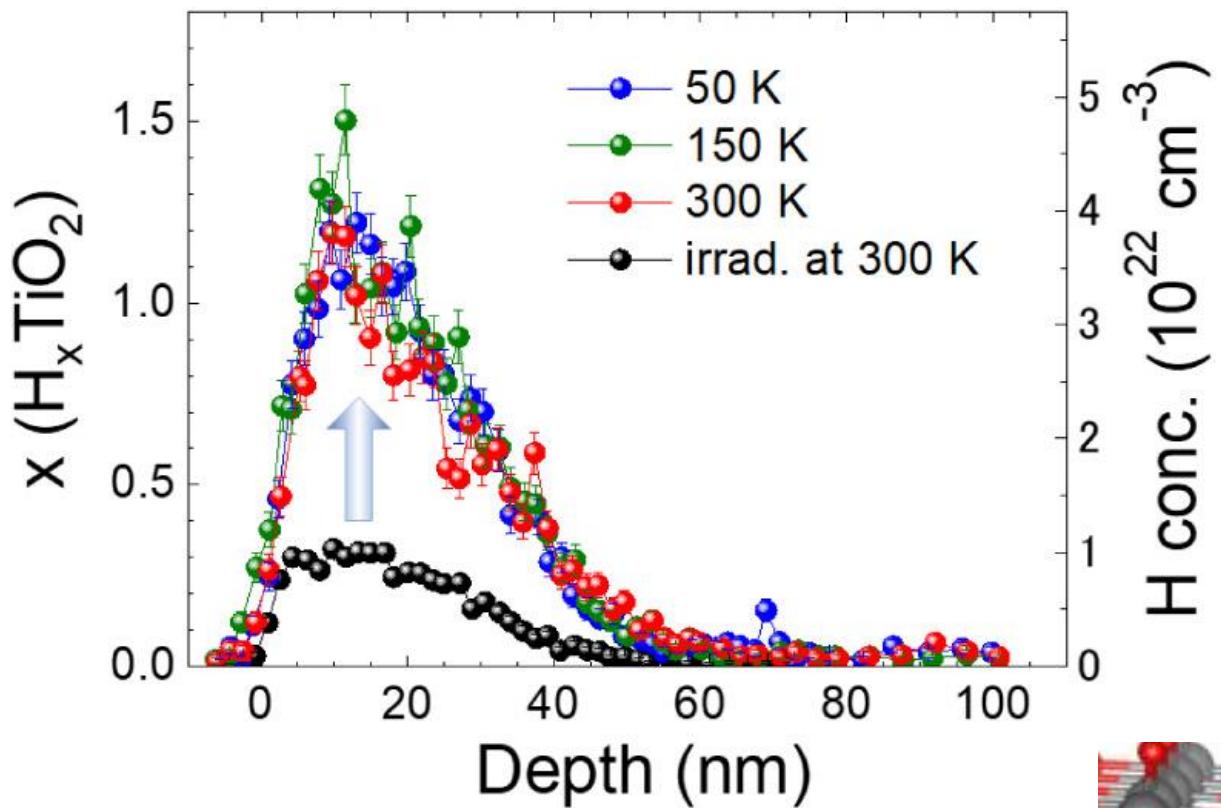
JPCC_128_8188



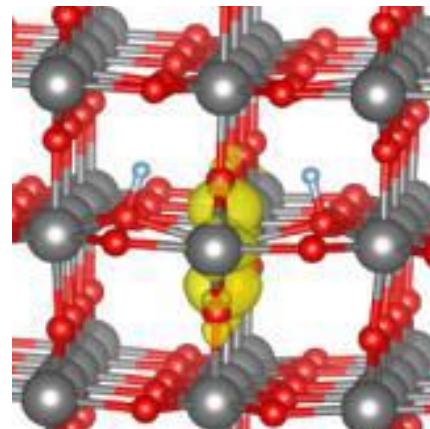
$U=0$: polaron gets large

Electron localization is important

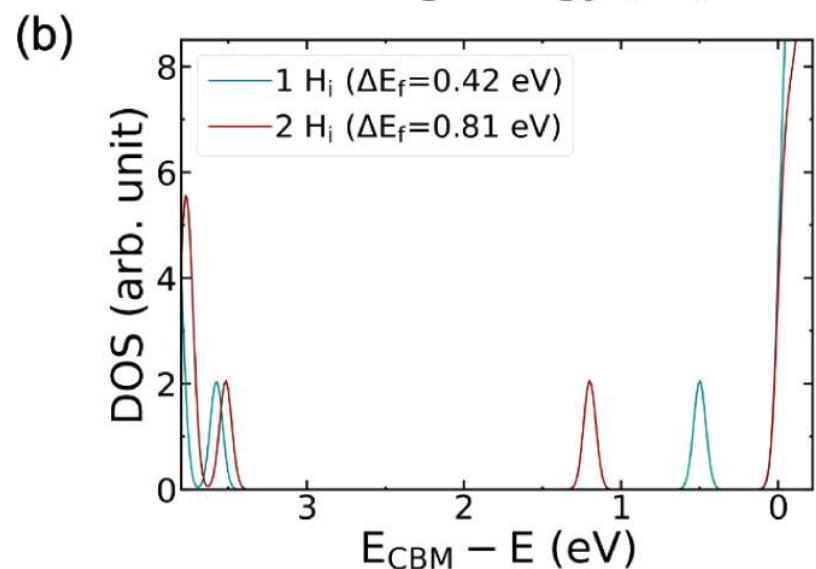
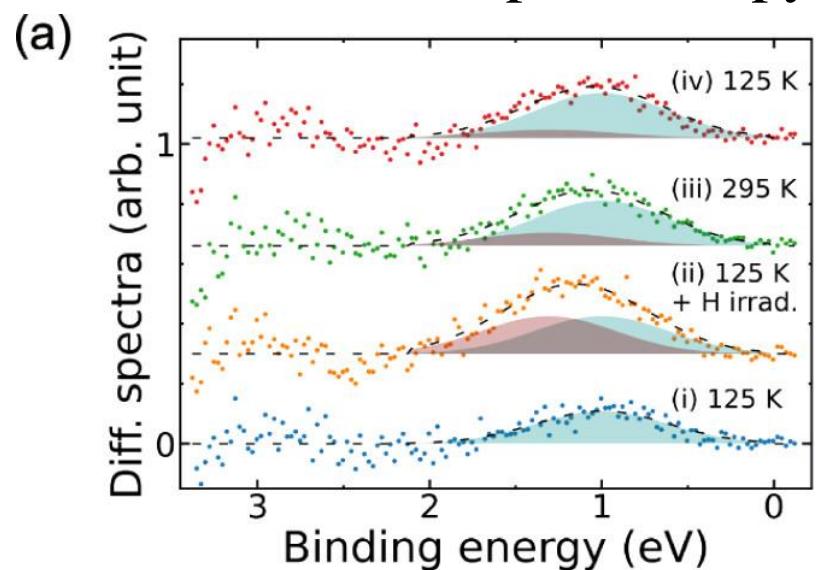
Hydrogen ion irradiation at low T



H concentration: TiO_2H_x ($x=1.2$)

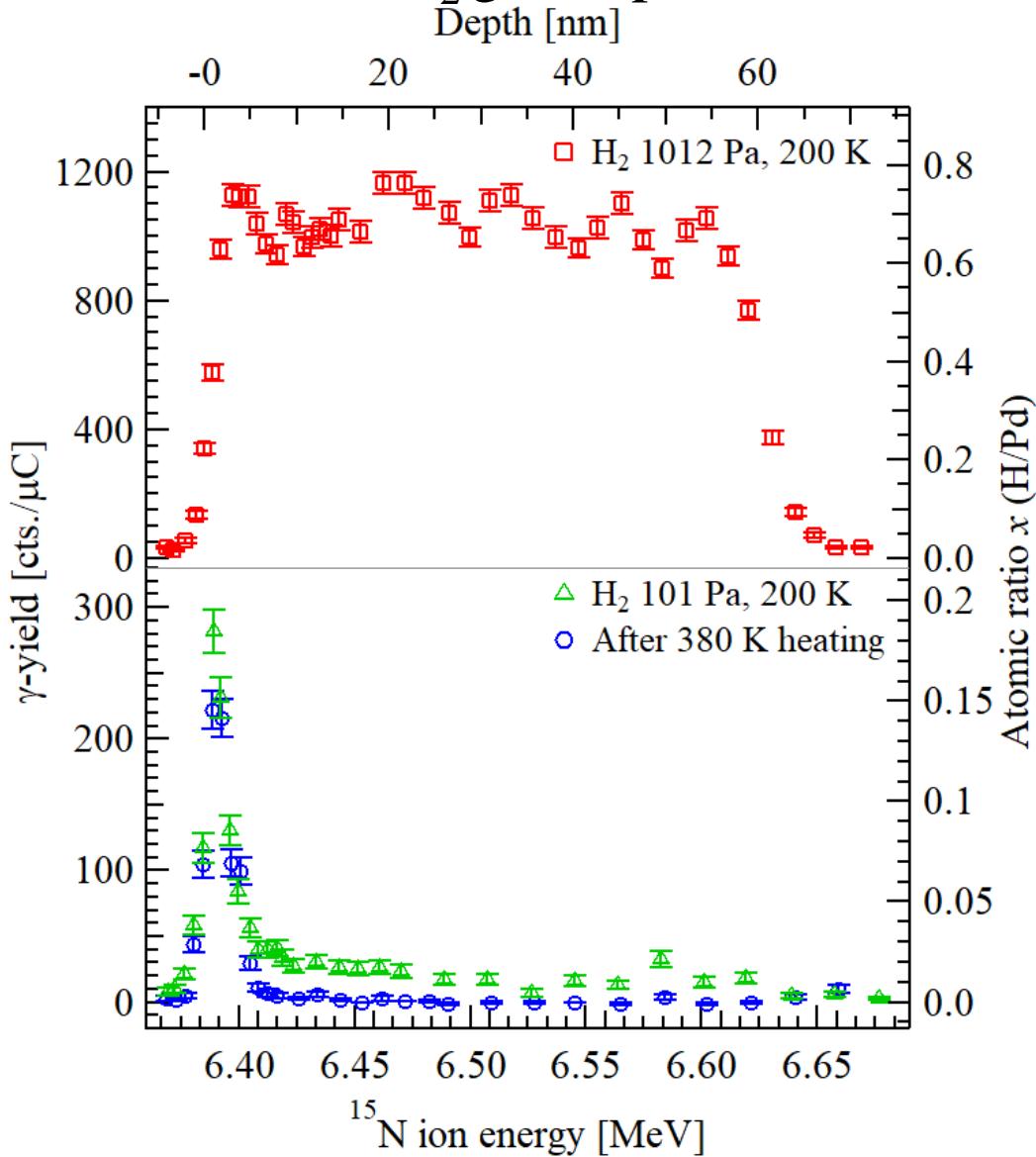


Photoemission spectroscopy



Pd: H₂ gas exposure and ion irradiation

Pd film (60 nm): H₂ gas exposure



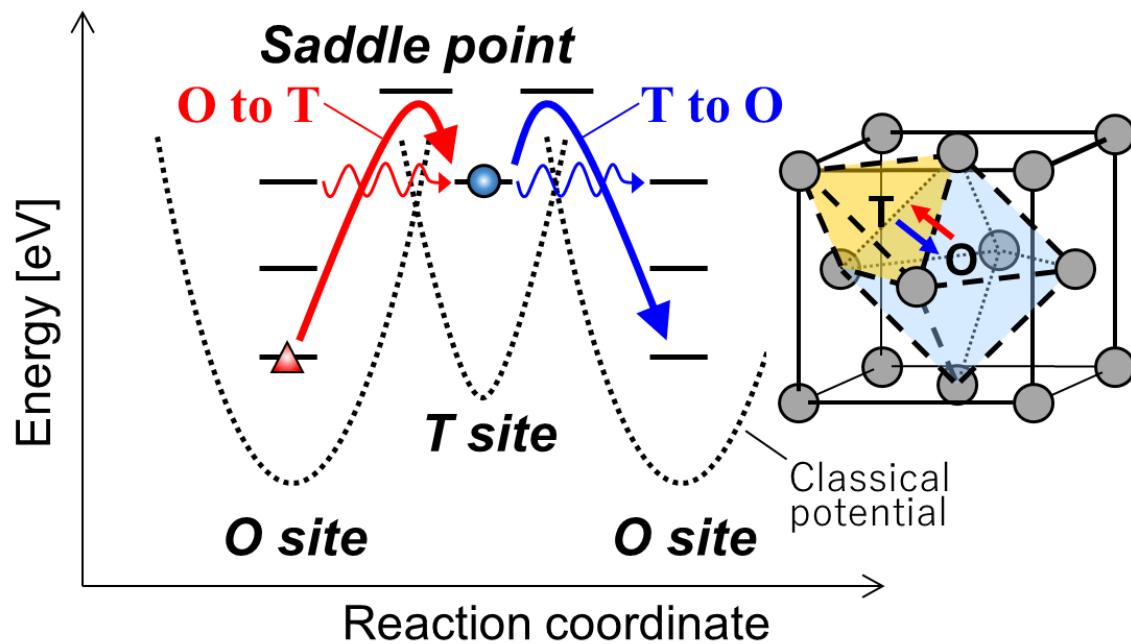
H ion irradiation of 0.5-2 keV at ~50 K
Pd(100) crystal

Partial occupation of metastable T site

E=6.42MeV:
depth~10nm

Line scan

Before & after annealing at 80 K

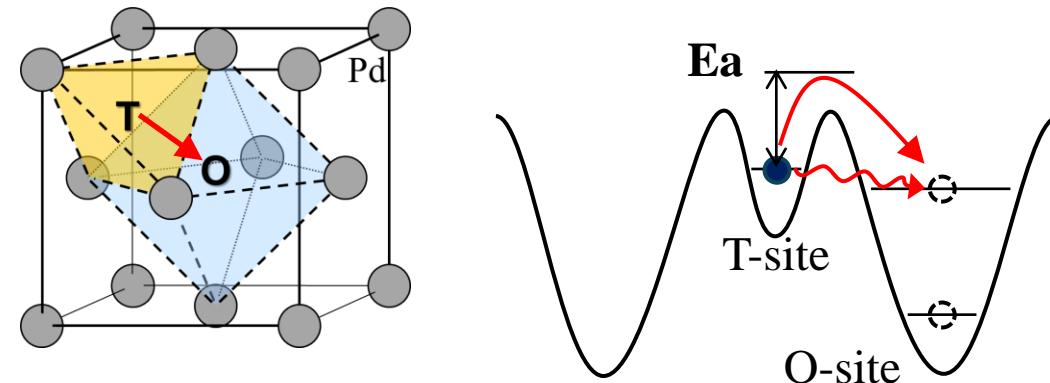


Shallow dip at $<100>$:

- ➡ O (50%) and T (50%)
- ➡ Move from T to O at 80 K

Temperature dependence of hopping rate

H/Pd : ~0.14



- ② 80 K>T>30 K: slightly T-dependent
Phonon-assisted tunneling

✓ Dressed electron
electron-proton coupling

- ① T>80 K: Arrhenius
Thermal over-barrier
- ③ T<30 K: nearly T-indep
Quantum tunneling

Summary

Hydrogen (atom and ion) interaction with metal oxides and metals Characterization by NRA

1. Metal oxides

SrTiO_3 : surface adsorption

insulator → metal

ReNiO_3 : adsorption + in-diffusion

metal → Insulator

HEPO: adsorption + in-diffusion

remain insulating

TiO_2 : near-surface accumulation by H ion irradiation

faster diffusion in anatase than rutile due to polaron effects

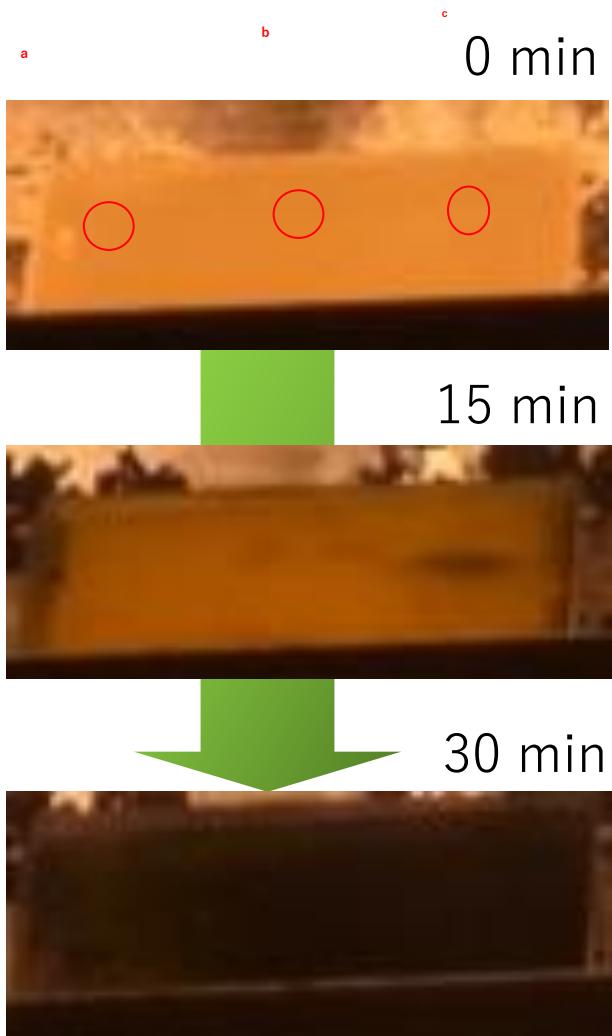
2. Metals

Metastable hydride formation by H ion irradiation,

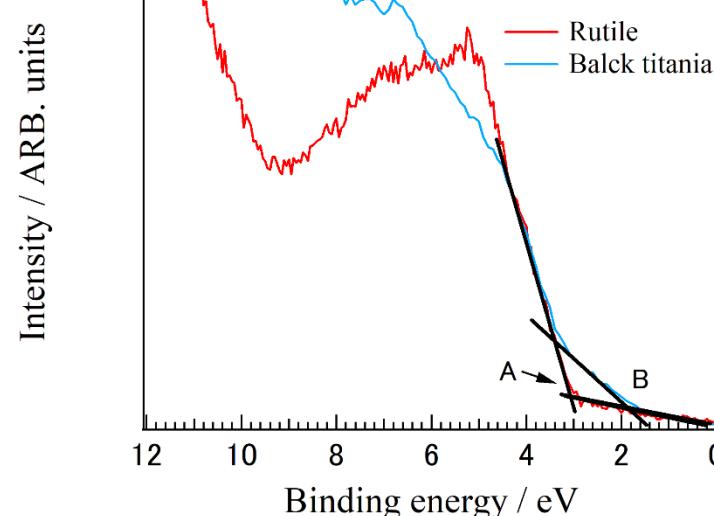
Pd: T(50%) and O(50%) site occupation

Pt: mostly stable T site occupation

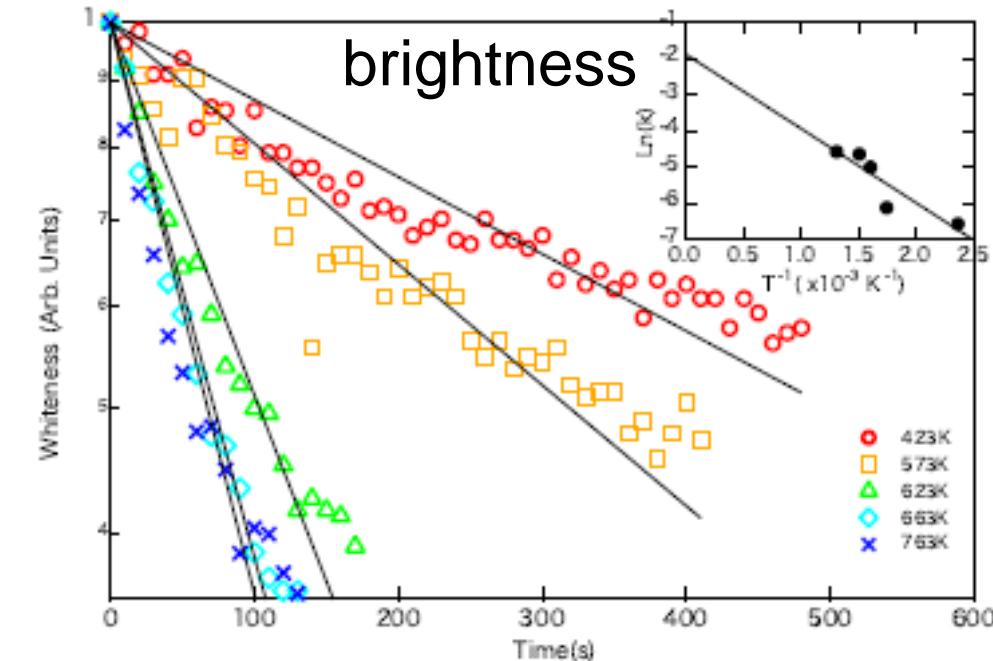
Atomic H dose at high T



Color change to black
Substantial reduction



Temperature dependence

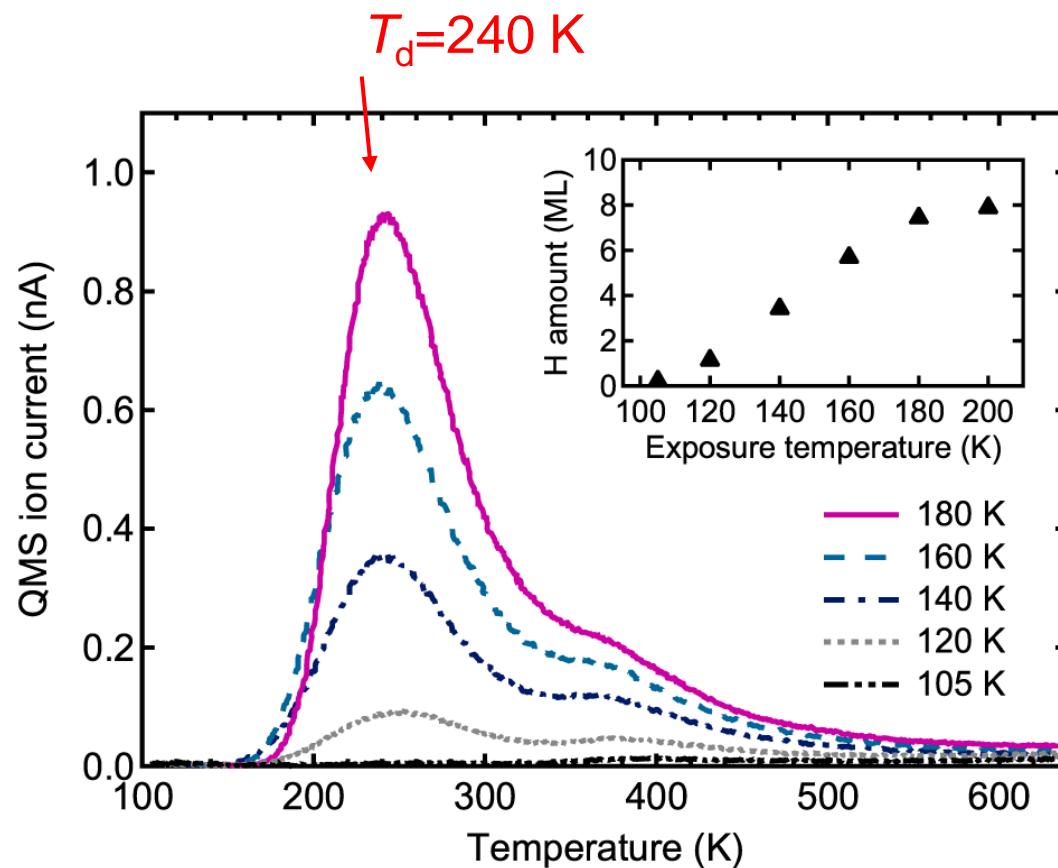


VBM~band gap
w/o H: 3.36 eV
w/ H : 1.88 eV

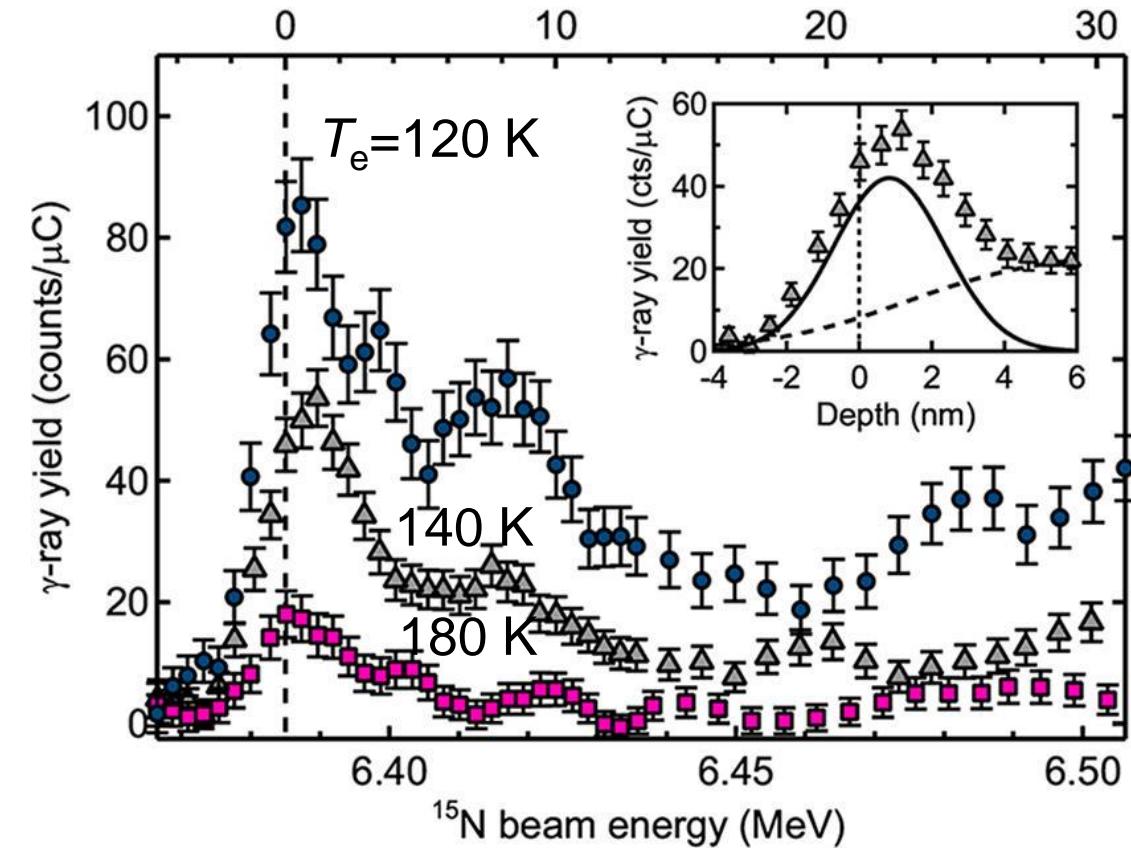
水素吸蔵材料：本当に吸蔵しているか？

$\text{Au}_{0.3}\text{Pd}_{0.7}$ 合金

H_2 热脱離分光

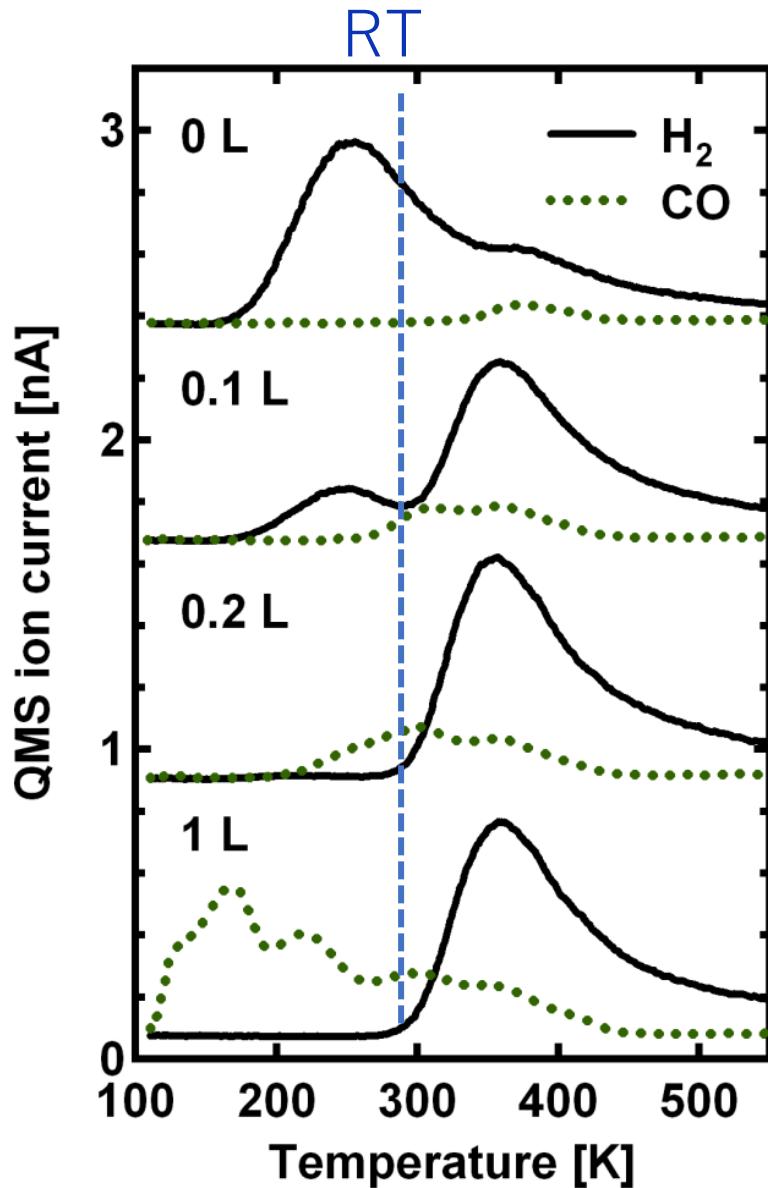


NRA 水素の深さプロファイル
Depth (nm)

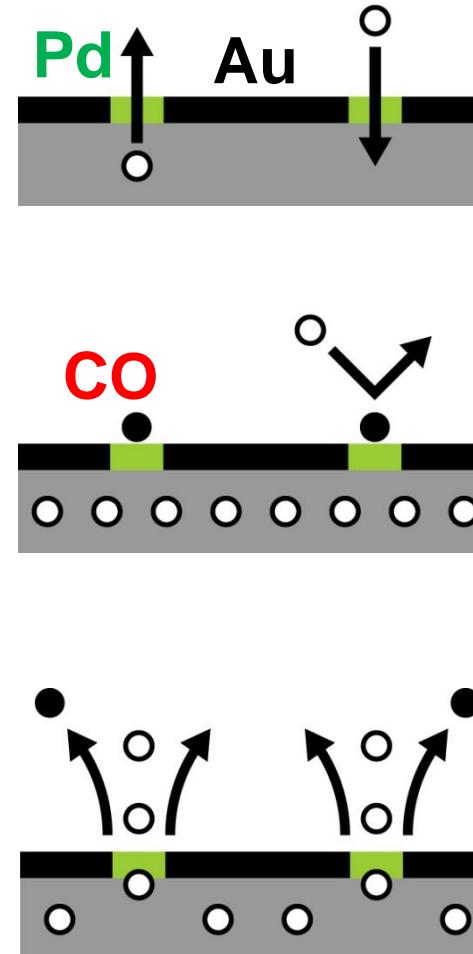


(S. Ogura et al., J. Phys. Chem. C 117, 9366 (2013))

表面で放出温度を制御する $\text{Au}_{0.3}\text{Pd}_{0.7}(110)$



Molecular cap by CO



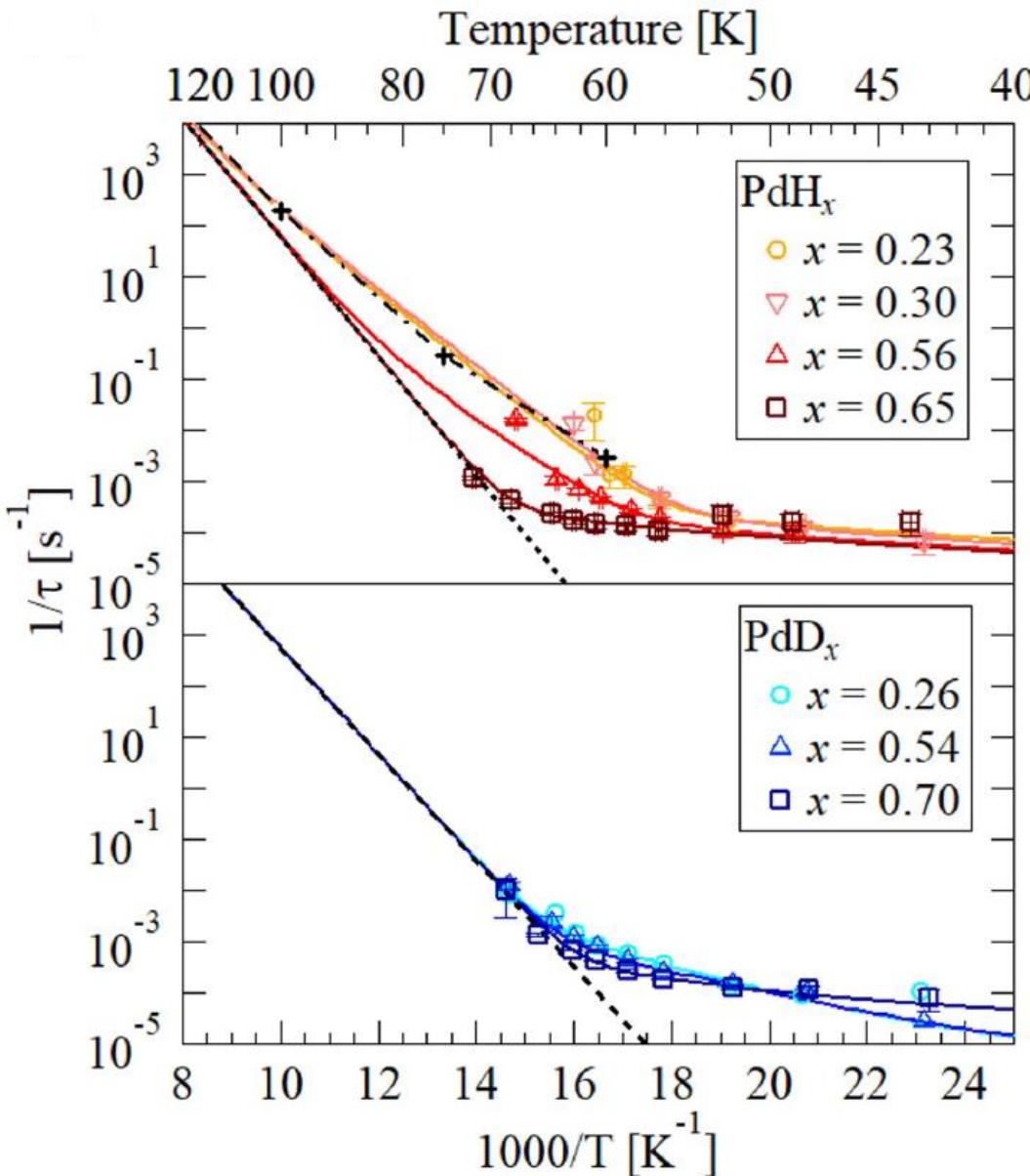
As prepared:

H_2 desorption via Pd below RT
(H does not like gold)

Cap with CO
stabilize H in bulk

Remove CO
 H_2 desorption

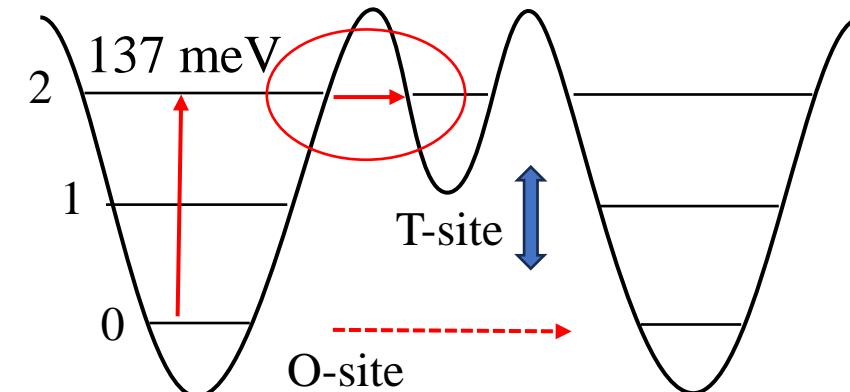
H diffusion: classical to quantum crossover



熱拡散 $v_0 \exp(-\frac{E_a}{kT})$

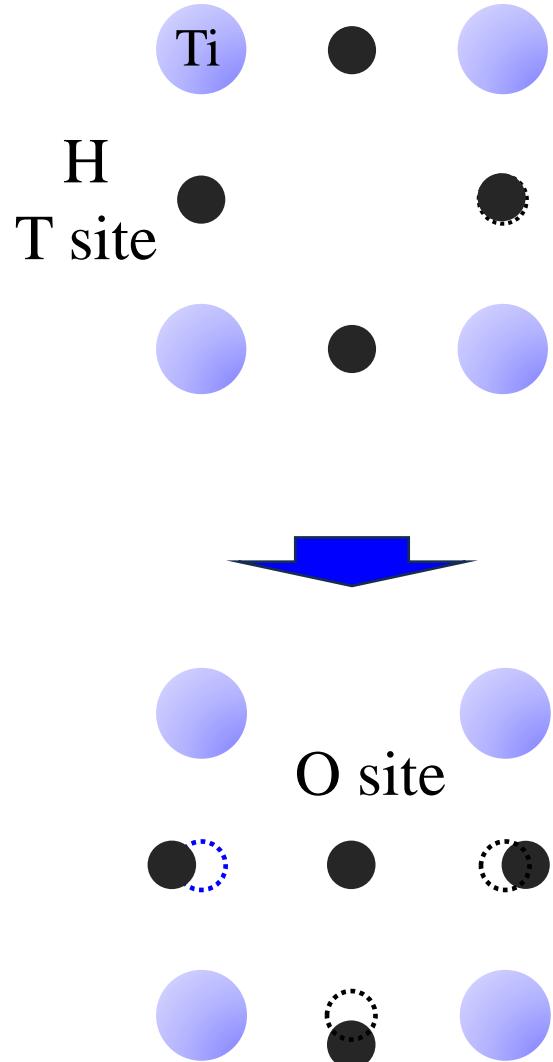
振動励起トンネル拡散 $v_1 \exp(-\frac{E_1}{kT})$

トンネル拡散 $v_3 T^\alpha$

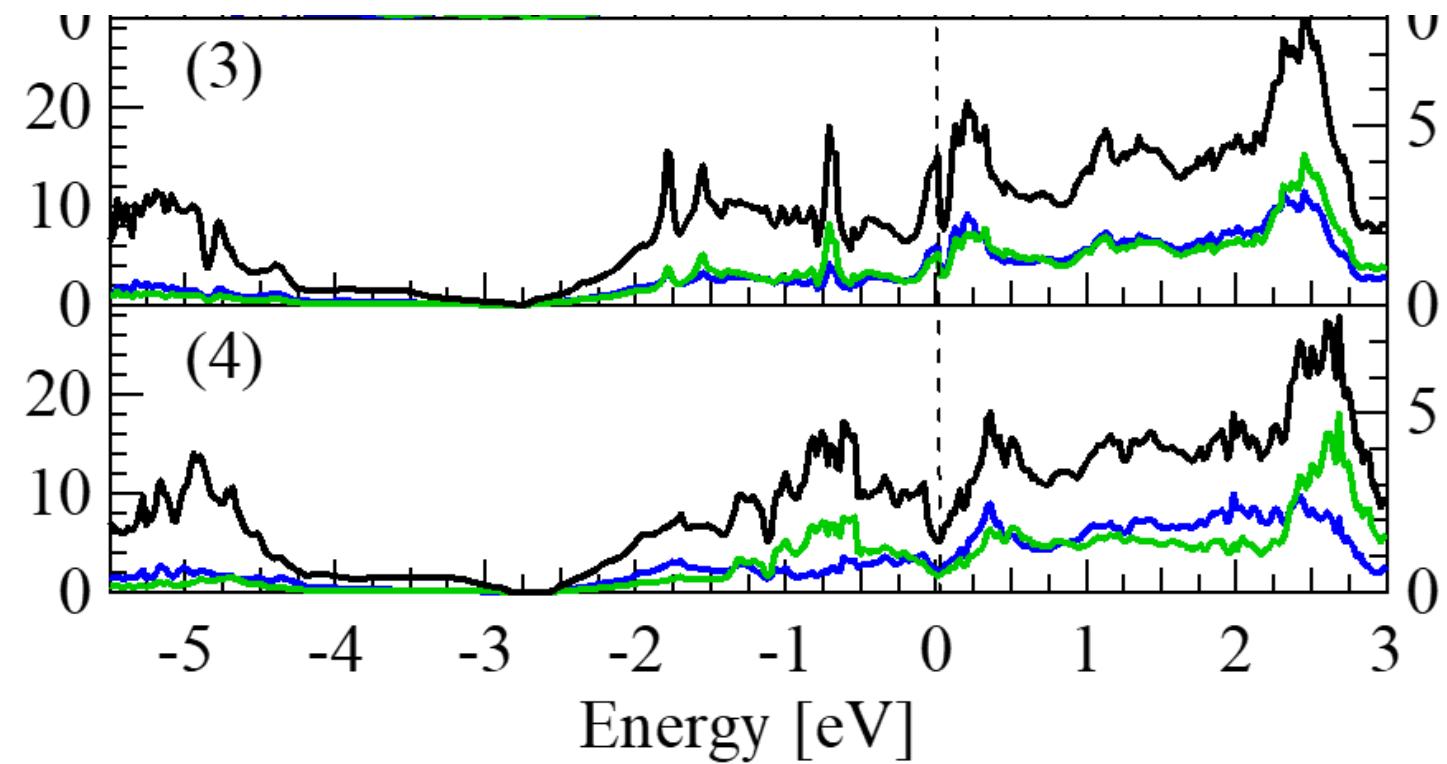


(T. Ozawa et al., J. Phys. Chem. Solids 185, 111741 (2023))

Effects of O site occupation



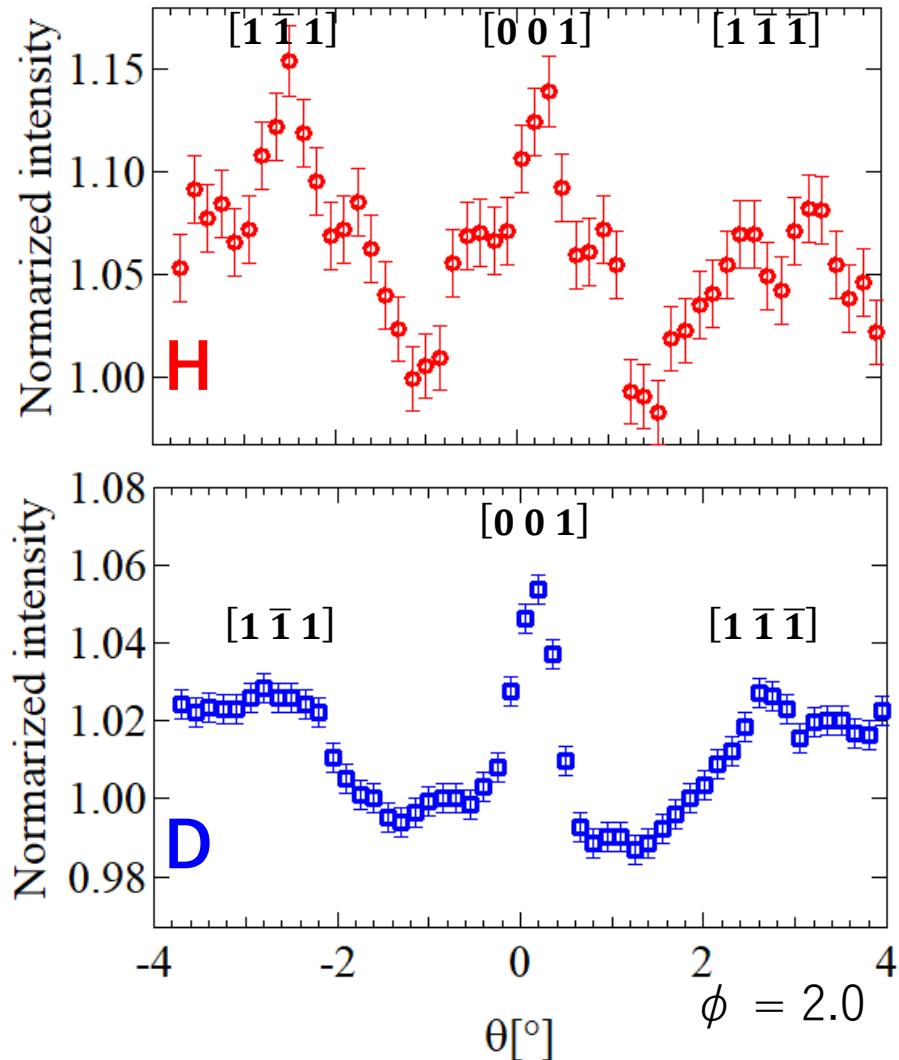
DOS by DFT



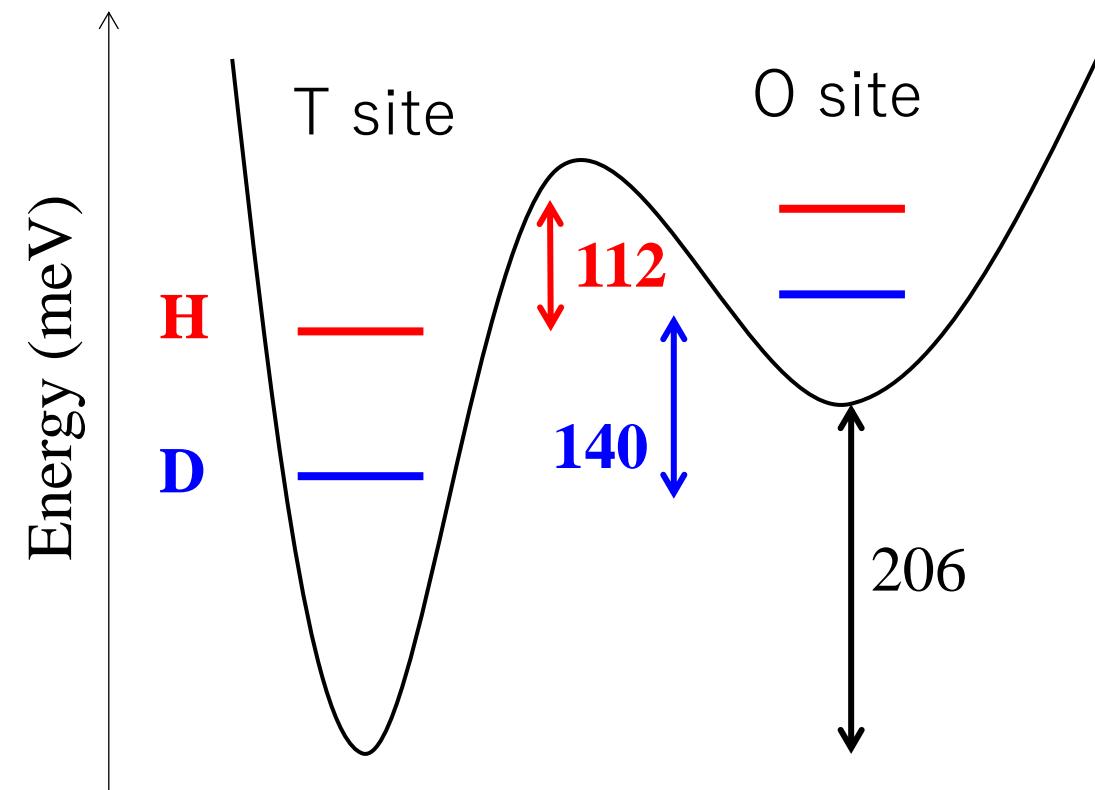
- Further split of DOS due to symmetry lowering (=H Jahn-Teller effect)
- Slight shift (0.2 \AA) of H location at the T site

Isotope effect: effects of ZPE

TiH_{0.6}D_{1.25} (110) (100 nm) /MgO(110)



$$ZPE = \frac{1}{2} \hbar \sqrt{\frac{k}{m}} \quad (1D)$$



D exclusively occupies the T site
because of the zero-point vibration effect.